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DFMA ASPECTS IN THE DESIGN OF A TRANSFER LINE FOR OFF-LINE ION SOURCES

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## PREFACE

The work presented in this thesis has been carried out at the JYFL accelerator laboratory at the university of Jyväskylä.

I Would like to express my gratitude towards my supervisors, Prof., Ph.D Ari Jokinen for guidance, Harri Eskelinen for his humble, yet analytic, problem solving approach that I have tried to adapt. Special thanks are due to Veli Kolhinen for his patience towards my curiosity as well as for his never ending will to share his knowledge and support. Brother, you have been a great tutor and a valuable friend. The help and time my roommate Juho Rissanen contributed, was indispensable especially as I tried to get familiar with all the wonders of $\mathrm{AT}_{\mathrm{E}} \mathrm{X}$.

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# TIIVISTELMÄ 

Lappeenrannan teknillinen yliopisto<br>Teknillinen tiedekunta<br>Konetekniikan koulutusohjelma

Kari Rytkönen

DFMA:n hyödyntäminen testi-ionilähteiden siirtolinjan suunnittelussa
Diplomityö

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145 sivua, 30 kuvaa, 8 taulukkoa, 44 liitettä

Työn tarkastajat: Professori Juha Varis
TkT Harri Eskelinen

Hakusanat: DFMA, siirtolinja, ioni-optinen simulointi, tyhjökammio, ionilähde.
Keywords: DFMA, transfer line, ion optical simulation, vacuum chamber, ion source.
Tässä työssä esitellään DFMA, jota käytetään siirtolinjan suunnittelussa yksinkertaistamaan osien valmistusta, helpottamaan kokoonpanoa ja asennusta sekä alentamaan kustannuksia. Siirtolinjan rakenne, pääkomponentit ja piirustukset esitellään tässä työssä. Asennuksen helppoutta sekä valmistuksen ja asennuksen kustannuksia verrataan teräksisen rakenteen ja alumiiniprofiilijärjestelmän välillä.

ALARA-periaatetta on noudatettu minimoimaan säteilyaltistusta sijoittamalla testiionilähteet pois radioaktiiviselta alueelta.

ABSTRACT<br>Lappenranta University of Technology<br>Faculty of Technology<br>Training Programme of Mechanical Engineering<br>Kari Rytkönen<br>DFMA Aspects in the Design of a Transfer Line for Off-line Ion Sources<br>Master's Thesis<br>2013<br>145 pages, 30 figures, 8 tables, 44 appendices<br>Reviewers: D.Sc. (Tech.) Juha Varis<br>D.Sc. (Tech.) Harri Eskelinen

Keywords: DFMA, transfer line, ion optical simulations, vacuum chamber, ion source.
Hakusanat: design for manufacturing and assembly, siirtolinja, ioni-optinen simulointi, tyhjökammio, ionilähde.

In this thesis, the DFMA is presented and used for the purpose of having a design for a vertical transfer line that can be easily manufactured and assembled. The design of the transfer line, the major components and drawings are presented. The ease of assembly, the costs of manufacturing and differences between the use of steel structure and aluminum are compared.

The ALARA principle is followed to minimize the risk of radiation exposure by the means of locating the test ion sources outside the radioactive area.

## Explanation of symbols

| $q$ | charge state |
| :--- | :--- |
| $f_{c}$ | cyclotron frequency |
| $f_{\text {meas }}$ | frequency of the ion of interest |
| $f_{r e f}$ | frequency of the reference ion |
| $B$ | magnetic field |
| $m_{e}$ | mass of an electron |
| $m_{\text {meas }}$ | mass of the ion of interest |
| $m$ | mass of the particle |
| $T$ | measure for magnetic field strength |

## Explanation of acronyms

| ALARA | As Low As Reasonably Achievable. |
| :--- | :--- |
| CERN | Conseil Européen pour la Recherche Nucléaire |
| CPT | Canadian Penning Trap |
| DC | Direct Current |
| DFA | Design for Assembly |
| DFD | Design for Disassembly |
| DFM | Design for Manufacturing |
| DFMA | Design for Manufacturing and Assembly |
| ECR | Electron Cyclotron Resonance |
| ECRIS | ECR Ion Source |
| FC | Faraday Cup |
| FURIOS | Fast Universal Resonant laser Ion Source |
| GSI | Gesellshaft für Schwerionenforschung |
| HV | High Voltage |
| ICRP | International Commission on Radiological Protection |
| IGISOL | Ion Guide Isotope Separator On-Line |
| ISOL | Isotope Separator on Line |
| ISOLDE | Isotope Separator on Line Detector |
| ISOLTRAP | Penning trap mass spectrometer at ISOLDE |
| JYFL | Jyväskyän Yliopiston Fysiikan Laitos |
| LASER | Light Amplification by Stimulated Emission of Radiation |
| LEBIT | Low Energy Beam and Ion Trap |
| LISA | Light Ion Source Apparatus |
| MCP | Micro Channel Plate |
| MLLTRAP | Maier-Leibnitz Laboratory Penning TRAP mass spectrometer |
| MSU | Michigan State University |
| NSCL | National Superconducting Cyclotron Laboratory |
| PA | Potential Array |
| RFQ | Radio Frequency Quadrupole |
| SPIG | Sextupole Ion Guide |
| TITAN | TRIUMF's Ion Trap for Atomic and Nuclear science |
| TRIUMF | TRI-University Meson Facility |
|  |  |

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## 1. INTRODUCTION

DFMA was used to find construction for a Vertical Transfer Line. VDI 2221, a guideline for product development, was used in the design process.

To connect the test ion sources to the main beam line of the accelerator, a Vertical Transfer Line is required. DFMA, a system to create a design that simplifies and thus lowers the costs of manufacturing and assembly, was to be utilized in the design process of the Vertical Transfer Line, the vacuum chamber for the ion sources and the necessary supporting structures as well as other various equipment needed. The scope of research included the design of the mechanical construction of the supports and the design of the equipment of the Vertical Transfer Line, as well as the ion optical simulations of the equipment. Ion-optical tuning and valve automation were not included in the scope of research.

The mass difference measurement is an essential part of the scientific research at the Accelerator Laboratory of the University of Jyväskylä. More than 250 atomic masses of ground states or isomeric states of nuclei have been measured using JYFLTRAP [1-7].

Two methods are used to execute the measurements, either on-line or off-line experiments.

The new Vertical Transfer Line enables the combination of measurements of the unknown isotope of interest produced using a nuclear reaction with an ideal, stable reference isotope. To follow the ALARA principle when working in a radioactive area, and to avoid exposure to the hazardous radioactivity during the change to an off-line ion-source after a radioactive on-line experiment, a safer and time saving technique is required.

A control sample produced using an additional ion source outside the radioactive area for calibration instead of a particle accelerator offers a safe, fast and less cumbersome method of producing test ions when changing from on-line beam to off-line beam or switching between optional off-line ion sources.

Ion-optical simulations were used for the dimensioning of the ion optical equipment.

## 2. MOTIVATION

To design a new vertical off-line DFMA was used in order to achive simple, light and economical solution. IGISOL IV is the latest generation facility, based on the Ion Guide Isotope Separator On-Line (IGISOL) technique developed in Jyväskylä in the 1980's [8-12]. A 3D-illustration of the separator and beam lines from the K-130 and the MCC30/15 particle accelerators in the new laboratory are presented in Fig. 2.1.


Figure 2.1.: IGISOL IV Layout.

In this technique, a thin target is placed inside a gas cell (ion guide) aligned with a primary beam coming either from the K-130 or the MCC30/15 cyclotron. As the beam hits the target, nuclear reaction products recoil from the target and are stopped and thermalized in a noble gas (helium). The charge state of the ions gradually decreases due to collisions with the helium atoms and impurities leading to singly-charged ions [13, 14].

Precision mass measurements are based on the repeated measuring sequence of unknown and reference isotopes produced in the present system either in nuclear re-
actions (on-line) or using the ion sources (off-line). On-line and off-line sources are located in the same target chamber and simultaneous use is not possible.

A new arrangement and location for the off-line ion sources serves the current needs and in addition, gives the possibility to combine on-line ion beam (main beam line) and off-line ion beam (Vertical Transfer Line).

Heavy primary ions results in low background radiation, however light-ion beams specially for use in fission runs with a uranium target will cause neutron background radiation. This radiation will activate the surroundings in the target cave as well as the metal in the structures and equipments. Because of the hazardous level of radioactivity, the laboratory area of the test ion source may be unaccessible for a period of one week. Even after this, the radiation level is higher than the surroundings [15].

The International Commission on Radiological Protection (ICRP) recommends a system for limiting the doses received by persons. The system has three features for dose limitation: justification, optimization, and dose limitation. Optimization, known as the ALARA-principle, is followed at the laboratory, meaning that even after the waiting period, the exposure for the higher level of radiation should be avoided [15]. This suggests that the test ion sources should be located away from the radioactive main beam line to a non-radioactive location.

ALARA is an acronym formed from the phrase 'As Low as Reasonably Achievable'. The phrase refers to a principle of keeping radiation doses and releases of radioactive materials to the environment as low as can be achieved, based on technological and economic considerations.

In this thesis, the aim is to provide a control sample for calibration without the need to access to the target area of either the K-130 or MCC $30 / 15$ cyclotrons. Equipment to be calibrated by using offline ion sources would be all the ion optics between the ion source and the Penning trap, as well as the extraction line of Penning trap.

In this thesis, an Electric Discharge Ion Source and Carbon Cluster Ion Source are considered to be used in the vertical transfer line. Availability of a third ion source is a future option.

A Carbon cluster ion source improves the accuracy of the measured masses. The atomic mass unit $U$ is $1 / 12$ of the mass of a carbon- 12 atom, thus carbon clusters, that consists of several carbon- 12 atoms, privides an absolute calibration for a relative comparison between the reference sample and the sample of interest. For this reason, carbon clusters are also ideal for examining the systematic effects of Penning traps, such as the Penning trap scetrometer JYFLTRAP, used for atomic mass measurements of exotic nuclei. Carbon clusters are available over a broad mass range in
steps of 12 mass units. In addition, the mass of carbon clusters are almost equal to the mass of multiple carbon atoms, the only correction coming from the molecular binding energies of 7 eV per atom at most [16]

Main hypothesis:
Using DFMA a such a stucture can be designed that allows to calibrate the measuring sensors and measuring devices without a particle accelerator in operation can be designed.

Secondary hypothesis: Simultaneous calibration using a stable reference ion source with the main beam of the accelerator in operation. Ion source $A$ is the primary ion source. Connectivity of alternative ion sources $B$ and $C$ to be studied.

A $=$ Electric Discharge Ion Source
B $=$ Carbon Cluster
C $=$ Optional ion source
For the control sample, test ion sources and a Vertical Transfer Line to connect the equipment to the accelerator's main beam line are required.

A Vertical Transfer Line, including a layout of the ion source unit, vacuum chamber for the ion sources and its' supporting construction are to be designed, as well as other related equipment.

## 3. THEORETICAL BACKGROUND - ION SOURCES AND BEAM LINES

The purpose of the test ion source is to produce a reference ion beam of known stable material that functions as a control sample for the main ion beam of the material of interest for JYFLTRAP. These reference ions are used alternately with the ions extracted from the fission ion guide that functions as a target for the primary beam of the particle accelerator, either K-130 or MCC30/15 cyclotron. IGISOL IV and JYFLTRAP schematic presentation can be seen in Fig. 3.1.

### 3.1. Main Beam Line

In the JYFL accelerator laboratory there are three ion sources feeding the K130 cyclotron. Two of them are Electron Cyclotron Resonance Ion Sources (ECRIS) for heavy ions: JYFL 6.4 GHz ECRIS and JYFL 14 GHz ECRIS. The third is a filament-driven multi cusp type H-light ion source LIISA. The ECR ion sources are used for the production of highly-charged ion beams for nuclear and material physics experiments. LIISA is used for producing intensive proton beams for nuclear physics experiments and medical isotope production.


Figure 3.1.: The old IGISOL-3 setup and JYFLTRAP. A schematic layout of the equipment, V.-V. Elomaa, 2009 [16]. IGISOL consists of a target chamber connected to a beam line of a cyclotron, he-buffer gas feed, Sextuple ion Guide, SPIG, followed by a dipole magnet, an electrostatic switchyard with a silicon (Si) detector, Faraday cup, and Micro Channel Plate, or MCP detector.

### 3.1.1. The Front-end setup

The front-end setup on the main beam line from the K-130 and MCC 15/30 cyclotrons consists of a target chamber, an extractor chamber and a ground electrode. The target chamber includes a fission ion guide, a buffer gas inlet and SPIG. The extractor electrode is placed in the extractor chamber.

The primary ion source is positioned as the main equipment in the front-end setup. The primary beam from the cyclotron arrives to the target chamber that sitting at +30 kV potential, hitting the target in a fission ion guide. The resulting fission fragments are stopped and extrated towards a SPIG. From the SPIG, the fission fragments pass the extractor electrode that is at +20 kV potential, and proceed further to the ground electrode that is at 0 V potential. Karvonen, 2010 [17]. The front-end setup is presented in Fig. 3.2 and the primary ion source can be seen in Fig. 3.3.


Figure 3.2.: IGISOL IV front-end setup. In the target chamber, the primary beam from the cyclotron passes through an uranium target mounted in the Fission Ion Guide. The Sextupole Ion Guide, SPIG, guides the fission fragments to the extractor electrode in the extractor chamber. Karvonen, 2010 [17].


Figure 3.3.: Operational principle of the Fission Ion Guide of IGISOL IV mounted on the primary beam line. The nuclear reaction products recoiling out of the target in a He-buffer gas filled chamber are transferred to SPIG electrode, that gets the ions to the mass seoarator with a final accelerating potential of +30 keV Elomaa, 2009 [16] Rissanen, 2011 [13].

### 3.1.2. Dipole Magnet

Ions are accelerated to 30 keV and mass separated by a $55^{\circ}$ dipole magnet [18]. The selectivity of a curve shaped dipole magnet is based on the masses of the particles. The centerline of the magnet has a certain radius. All the wanted particles having the correct mass will travel along the centerline, while heavier particles will depart off the centerline, with a larger radius at the exit. Particles will be forced by the magnet to have a tighter curve on the inner side of the magnet and thus be eliminated accordingly. The position of the $55^{\circ}$-dipole magnet can be seen in a schematic presentation Fig. 3.1.

### 3.1.3. Radio Frequency Quadrupole Ion Beam Cooler

The Radio Frequency Quadrupole or RFQ cooler is used for decelerating, stopping and cooling the ions coming from the mass separator. The principle of collecting and bunching the ions before re-acceleration is presented in Fig. 3.5. Ions are collected in a potential well, and then released by lowering the potential wall. The ions entering the RF-quadrupole are extracted and accelerated towards 1 keV the Penning trap. The ions can also be guided to the laser spectroscopy station, whereby they are accelerated to $30-40 \mathrm{keV}$. The mechanical construction of the RFQ-cooler is shown in Fig. 3.4.


Figure 3.4.: Construction of Radio Frequency Quadrupole, RFQ, used for cooling and bunching the ions.


Figure 3.5.: Ions are captured by creating a potential wall using segmental rods and DC fields. Potential wall is lowered and ions released.

### 3.1.4. JYFLTRAP



Figure 3.6.: Trap electrodes of the purification- and precision traps within the 7-T superconducting magnet of JYFLTRAP. Electrodes are numbered from 1 to 38. A = ring electrodes (19th and 30th), $B=$ correction electrode, $C=$ end caps, $D=\varnothing 3 \mathrm{~mm}$ diaphragm,$E=\varnothing 1.5 \mathrm{~mm}$ diaphragm [19].

The JYFLTRAP Penning trap mass spectrometer can be used for precise atomic mass determination of short-living radioactive atoms [20]. Penning trap experiments can be found also at the research facilities including ISOLTRAP at CERN, Switzerland, SHIPTRAP at GSI (Gesellschaft für Schwerionenforschung), Darmstadt, Germany, Low Energy Beam and Ion Trap (LEBIT) at the National Superconducting Cyclotron Laboratory (NSCL) in Michigan State University (MSU), U.S.A, Canadian Penning Trap (CPT) at Argonne National Laboratory, U.S.A, TITAN (TRIUMF's Ion Trap for Atomic and Nuclear science) at TRIUMF, run by a consortium of sixteen Canadian universities and located at Vancouver, BC, Canada.

The JYFLTRAP ion trap setup [21] consists of three traps, a linear Paul trap [22] and two Penning traps in a 7 Tesla superconducting magnet. The first trap is used to purify the ion sample from isobaric contaminants [23] which cannot be removed by the dipole magnet. The purified sample can be sent directly to a detector arrangement for nuclear spectroscopy located downstream form the magnet or can be injected into the second trap for precision atomic mass measurements.

A schematic of the two cylindrical traps is presented in Fig. 3.6. The magnet is used to create a homogenous magnetic field, $[16,19]$

The physical dimensions of the magnet body includes a diameter $D_{\text {max }}=1350 \mathrm{~mm}$, and a measured length $L_{\text {measured }}=1009 \mathrm{~mm}$. A similar solution with a 7 T superconducting magnet and Penning trap mass spectrometer MLLTRAP is in use at the Maier-Leibnitz Laboratory Garching, Germany [24], SHIPTRAP at GSI and TRIGA-TRAP Johannes Gutenberg-Universität, Mainz, Germany.

The cyclotron frequencies are measured for both the control sample and for the sample of interest. For the ratio calculation, the control sample is from the test ion source and the material of interest is from the main beam line of the accelerator.

The cyclotron frequency $f_{c}$ is

$$
\begin{equation*}
f_{c}=\frac{q B}{2 \pi m} \tag{3.1}
\end{equation*}
$$

The cyclotron frequency ratio is calculated by dividing the frequency value of material of interest with the frequecy of the control ion beam prior to and after each measurement of the ion beam of interest. This calculation helps to minimize the systematical uncertainity of the measured values. Several measurements are required to minimize the statistical error to the level where the systematic error will become dominant. The number of the control sample and test sample pairs during laboratory test run are numbered in the tens, if very accurate data is required. Relatively accurate information can, however, be achieved even with only few measurements.

The frequency of the reference ion $f_{\text {ref }}$ and the frequency of the ion of interest $f_{\text {meas }}$ are measured to calculate the mass of the ion $m_{\text {meas }}$ of interest using equation (3.2). $m_{e}$ is the mass of an electron.

$$
\begin{equation*}
m_{\text {meas }}=\frac{f_{\text {ref }}}{f_{\text {meas }}}\left(m_{\text {ref }}-m_{e}\right)+m_{e} \tag{3.2}
\end{equation*}
$$

The mean frequency for the reference ion is interpolated from a linear least-square fit of two data points.

One of the systematic effects present in a Penning trap mass spectrometer depends on the mass difference between the ion of interest and reference ion. This effect can arise due to imperfections of the electrostatic field of the Penning trap or misalignment between the magnetic and electric field axis [16,25-27].

### 3.2. Vertical Transfer Line

In an ideal transfer line, ion-optical corrections are not taken into consideration. For this reason, an ideal line can be compact. Limitations and errors existing in the real environment forces to add equipment to correct the imperfections of the beam and increasing the dimensions of the line. ion-optical simulations are used to find an optimal beam and construction.

### 3.2.1. Test Ion Sources

The purpose of the test ion source is to provide a reference beam to the main beam of the accelerator. The control sample from the ion source receives its' kinetic energy
in the beginning of the process. High voltage, order of 30 kV is used to extract the ions from the chamber of the ion source.

However, if more than one ion source is to be used, a quadrupole deflector is required to bend the ion beams of optional ion sources on to the axis of transfer line. The bending capability of a quadrupole deflector is limited and therefore a voltage of $<1 \mathrm{kV}$ is used. In this case, the final acceleration must be done after the quadrupole deflector, see Fig. 3.8. The control ion beam does not receive any additional acceleration after this point.

After acceleration, the control beam requires shaping and guiding to reach the target area, that is in this case, the Penning trap. Guiding the control ion beam through the transfer line requires adjustments of the beam on transfer line, both vertical- and horizontal correction. Vertical line is from the test ion source(s) to the $90^{\circ}$ bender, that turns the ion beam to the horizontal main beam line, originating from the accelerator.

The preliminary layout with some main components of the vertical transfer line of the IGISOL IV-isotope separator is presented in Fig. 3.7.


Figure 3.7.: Preliminary layout of the Vertical Transfer Line assembly showing some of the main components. On top, bellows followed by a valve and double $X Y$-deflector. Parts are supported by a quadrupole-triplet and diagnostic box that are attached to horizontally adjustable equipment racks and further to wall supports. A valve below isolates the vertical line of the $90^{\circ}$ bender and the horizontal main beam line. A bellow is used to allow adjustment connecting the vertical line and the $90^{\circ}$ bender together. Vacuum pumps are not shown.

### 3.2.2. Quadrupole Deflector

A quadrupole deflector is used to bend the ion beam $90^{\circ}$, in Fig. 3.8 from the horizontal level, down to the vertical line. The beam is later to be manipulated by other ion-optical equipment. The quadrupole deflector consists of four metallic electrodes, where the voltage is applied.


Figure 3.8.: Quadrupole Deflector assembly, without a vacuum chamber. Main electrodes and shim electrodes are used to bend the beam.

### 3.2.3. Quadrupole-Triplet



Figure 3.9.: Quadrupole Triplet, transparent view, three sets of poles, each set consisting of a group of electrodes separated by insulating rings.

A quadrupole-triplet consists of three sets of two positively and two negatively charged electrodes, see Fig. 3.9. The order of the sets may be either +-+ or -+- , depending on the desired effect for the beam. One quadrupole consists of two circuits and electrode pairs; one is focusing and another defocussing.

### 3.2.4. Double XY-deflector

The double XY-deflector is to control the position of the beam. A double XYdeflector is formed by using two XY-deflectors back-to-back. Two XY-deflectors enables parallel transition for the beam. This function is useful if the beam is not on the centerline of the transfer line. A cross section of the double XY-deflector is presented in figure 3.11. A transparent view of the double XY-deflector is presented in Fig. 3.10.


Figure 3.10.: double $X Y$ deflector. Vacuum chamber is presented transparent.


Figure 3.11.: double $X Y$ cross section, the ion-optical elements shown in yellow.

### 3.2.5. Diagnostic Box



Figure 3.12.: Diagnostic box, without the equipment to be installed to the flanges. Only the Faraday cup is illustrated, however the actuator for the Faraday cup is not shown. Optional flanges are closed with blank flanges.

The diagnostic box is a cylindrical vacuum chamber with several variable sized flanges for the measuring equipment or devices. On the vertical transfer line, the diagnostic box is used as a platform for a vacuum pump and Faraday cup with an actuator. Other optional inlets are covered with blank flanges, giving the option for the installation of additional equipment. Currently, the new diagnostic boxes are ordered with standard dimensions. This means that due to the limited height between the ceiling and $90^{\circ}$ bender, other equipment and layout options are to be studied in anticipation for designing a more compact diagnostic box. A 3D image of the diagnostic box showing the position of a Faraday cup inside the chamber can be seen in Fig. 3.12.

### 3.2.6. Vacuum pumps

Vacuum pumping is needed for the vertical line as the line needs to be isolated from the ion sources above and from the main line below. The first gate valve is placed just above the $90^{\circ}$ bender and another one to be placed after the double XY, seen in Fig. 3.7. The primary pump is to be placed to the inlet flange of the diagnostic box.

For this position, a turbomolecular pump is considered to be ideal because of its size and relatively easy installation. A existing Edwards STP-301 turbomolecular pump has been considered to be used, as well as an Edwards XDS 10 scroll pump backing the turbomolecular pump.

### 3.2.7. Einzel lens

An Einzel lens provides a cylindrical-symmetric profile for the beam. It is constructed of three ring-shaped electrodes. Voltage is applied to the middle electrode, often longer than the electrodes at either end. This voltage causes a electric field that shapes the beam equally if the beam is on the centerline of the lens. If the beam is offset when arriving to the lens, it will be deflected aside from the intended beam axis after the Einzel lens.

### 3.3. Ion sources

### 3.3.1. Electric Discharge Ion Source

An electric discharge ion source will be the preliminary source for a control sample. A vertical placement of the source is ideal as there is no need for bending the beam. The electric discharge ion source is presented in Fig. 3.13. Other type of source need to be installed in a horizontal position, requiring a quadrupole deflector, presented in Fig. 3.8.


Figure 3.13.: Discharge ion source with two different metals, Mo and Ru plates.

### 3.3.2. Carbon Cluster Ion Source

The carbon cluster source, presented in Fig. 3.14 is under development. Carbon ion beam transport is presented in Fig.3.15.
upport flange (KF100)


Figure 3.14.: Detailed view showing the detailed structure and the main parts of the carbon cluster ion source. V.-V. Elomaa, [16]


Figure 3.15.: Presentation of the carbon ion beam transport from horizontal level to the vertical transfer line through a quadrupole deflector that bends the beam. V.-V. Elomaa [28].

### 3.3.3. Optional ion source

An additional connection will be applied to maintain the possibility for an optional source to be developed in the future. Caesium and/or Rb ion sources could be considered as alternatives. Both metals liquidize and vaporize above room temperature, $30^{\circ} \mathrm{C}$. This property is utilized by heating the metal in a small volume tank. Vaporized metal gas is released through a valve into a heated metal wire, thus ionizing.

### 3.3.4. Ion-optical calculations

Ion-optical calculations does not include any valves nor diagnostic boxes. Such equipment, depending on their physical dimensions, affects the optical behavior of the beam. The starting point for the calculations is the ion source. The goal is to achieve the desired beam quality in a certain point. The ion-optical design of the vertical line as well as the IGISOL beam line is based on GIOS simulations. GIOS is an ion optics code used to determine optical properties of intense ion beams.

### 3.3.5. Control sampling methods for the calibration

The ion source defines the nature of the ion beam, i.e. density. The ion optics are used to focus the beam in such a way that it will form the desired shape. The quadrupole-triplet affects the phase space of the ion beam. The vacuum pipe defines the maximum size of the ion beam. For the current vacuum pipe used for the transfer line, the diameter being 110 mm , the diameter of the ion beam varies between 5 to 30 mm . The eventual size will be adjusted by double XY-deflector as well as the positioning of the beam on the pipeline.

In the future, a Carbon Cluster is considered to be an alternative ion source to a Discharge Ion Source on the IGISOL IV line. The additional sources also require a new vacuum chamber design to adapt the different versions of ion sources and other equipment. In production of the discharge, voltage and the vacuum chamber pressure are important factors used for adjustment.

## 4. METHODS

In this thesis, for the design of the Vertical Transer Line, a combination of different systematic engineering methodologies are utilized. DFMA principles are used for the evaluation of manufacturability and ergonomics. For the manufacturability of the parts and equipment, both existing and new, DFMA 1 forms are used. DFMA2 forms are used for the evaluation of the ergonomics in assembly. To support consistent engineering, the seven-stage VDI-2221 is used. The principle is to re-evaluate the ideas between the stages and if necessary, make improvements to the design due to the possible new information found during the iteration process. These methods are used for the engineering of the support system of the Vertical Transfer Line.

In addition to the mechanical engineering, the ion-optical properties of the equipment affect the design and layout of the Vertical Transfer Line. ion-optical simulation is used to confirm and define the functional dimensions for the engineering of the components as well as to find the theoretically optimal voltage values for the testing to be used as start-up values. The last, seventh stage of VDI-2221 Final layout - is not studied until the final phase of this chapter, after ion-optical simulations.

DFMA is a combination of DFM - design for manufacture and DFA - design for assembly. DFMA can be utilized to achieve a balance between the benefits for both manufacturing and assembly. Eskelinen [29] sets several goals for DFMA; it aims to improve the integration between design and manufacturing, lowering costs, speeding up the product developement cycle, improve or increase quality, reliability and productivity and respond to customer requirements as well as shortening lead time.

Other methodologies like DFE = Design for Enviroment, DFD = Design for Disassembly, DFS=Design for Service or DFSS=Design for Six Sigma are not utilized on this study.

DFMA also has commercial applications, like a toolset combining Design for Manufacture and Assembly (DFMA) and software to customers product development process [30].

The motivation to use DFMA are varied, but the most common reasons are:

- Assembly costs
- Assembly time
- Reliability
- Total Time-to-Market

In this study, the total time-to-market has no remarkable significance due to the nature of the product, that is relatively unique research application as a part of a larger scale laboratory installation. Part of the product is also possible to install separately, so that it does not necessarily affect the use of other laboratory equipment and thus lowering the pressure to set a firm schedule for the installation.

Using DFMA is considered to have greater possibilities to lower assembly costs by using fewer parts, eliminating unique parts wherever possible, and decreasing the amount of labor required for assembly. DFMA is seen to shorten assembly time by utilizing standard assembly practices such as vertical assembly.

Increased reliability is achieved according to DFMA by lowering the number of parts, thus decreasing the chance of failure. Shorter total time-to-market for a product to go from conception to the consumer is considered to be shorter due to the quicker and smoother transition in the production phase when using DFMA in the development. This is achieved due to having a more complete and workable design the first time.

## Benefits of DFMA:

- Reduced part number and part counts
- Reduced assembly operation
- Reduced product lead-time
- Reduced packaging costs
- Increased productivity and efficiency
- Reduced material cost
- Reduction in overall system/product cost
- Improved product quality and reliability


### 4.1. Review of wishes and requirements

The list of requirements was collected at a startup meeting of this thesis and later interviews [31-34].

## Requirements:

- Control sample for calibration and ion-optical beam optimization without using the accelerator
- Valve automation
- HV-insulation between ion sources and the transfer line
- Vacuum compability of parts, equipment and HV-feed throughs
- Vacuum requirement order of $10^{-6}$ mbar
- General, HV- and radiation safety requirements
- Durable


## Wishes:

- Compact design, the components of the transfer line must fit on a space height of 3450 mm
- Light weight
- Low cost
- Easy installation and adjustability
- Use of standard parts

The scope of research included the design of the mechanical construction of the supports, design of the equipment of the Vertical Transfer Line, as well as the ion-optical simulations of the equipment. Automation, electrical control, local and computer controlled ion-optical tuning were not included in the scope of this research, and the related items mentioned on the list of requirements for the Vertical Transfer Line were not studied.

List of requirements for the design and engineering of the Vertical Transfer Line can be seen in Table 4.1 [31-34].


Figure 4.1.: New Laboratory, the support structure of the original $90^{\circ}$ bender installed. In the background, a hole and a vacuum pipe for the incoming accelerator line is shown. Similar hole is placed in the one meter thick radioactive protective concrete ceiling over the support. Room height is 3450 mm , so the concrete ceiling limits the layout of the mechanical components to be placed below it.

| List of Requirements for the Transfer Line | $\mathrm{R}=$ request <br> $\mathrm{W}=$ wish |
| :--- | :---: |
| Control sample for calibration and for ion-optical <br> beam optimization without using the accelerator. | R |
| Compact design, the components of the transfer <br> line must fit on a space height of 3450 mm. | W |
| Durable | R |
| Light weight | W |
| Low cost | W |
| General, HV- and radiation safety requirements | R |
| Easy installation and adjustability | W |
| Use of standard parts | W |
| Valve automation | R |
| HV-insulation between ion sources and the <br> transfer line | R |
| Vacuum compability of parts and equipment | R |
| Vacuum compability HV-feed through | R |
| Vacuum requirement order of $10^{-6} \mathrm{mbar}$ | R |
| Remote ion-optical tuning | W |
| Computer controlled Ion-optical tuning, <br> feedback of the set value. |  |

Table 4.1.: List of Requirements for the design and engineering of the vertical transfer line [31-34].

### 4.2. Current Vertical Transfer Line design

There is an existing transfer line that has been dismantled from IGISOL- 3 and parts are availlable for use. The original vertical transfer line can be seen in Fig. 4.2 on page 30 . The simplest solution would be to reinstall these existing parts in the new laboratory. The problems however are the space limitations, the original setup was relatively high and the height of the building was not a limiting factor.

In the new laboratory, a concrete ceiling limits the installation of the equipment on the floor level to the height of +3450 mm . Ceiling is of 1 m thick concrete to reduce the radioactive radiation coming from the accelerator line, which may scatter and affect the future ion sources that are to be placed above it. The ceiling is thinner around the 160 mm hole for the transfer line, apparently half a meter thick on an area of approximately $1 \mathrm{mx} 1,1 \mathrm{~m}$. This opening is to be filled by tiles after the installation of the transfer line equipment to minimize the radiation outside the 'hot' radioactive area. Incoming accelerator line can be seen in Fig. 4.1.

### 4.2.1. Functional structure of the product

The functional structure of the product describes the relations between the main parts and/or functions to achieve the goal for the equipment. A flow diagram can bee seen in figure 4.2.


Table 4.2.: Functional structure of the hot ion source, vertical transfer line and mass spectrometer


Figure 4.2.: The original vertical transfer line at IGISOL-3 before dismantling. The blue metal frames bolted on the white, vertical roof support beams are equipment racks, welded of steel profile. There are no limitations for the mechanical construction above, unlike the new premises, where the concrete ceiling limits the mechanical components to be placed within a room height of 3450 mm .

### 4.2.2. Evaluation of assembly and integration

Assembly of the existing structure in the new laboratory is considered to cause difficulties because of the heavy steel support for the equipment. As all the major components and related cabling, piping and their racks and supports are already installed to a limited space in the laboratory, the heavy steel structures are considered difficult to be installed using only manpower. No overhead cranes are available in this part of the laboratory.

In the original layout the blue painted equipment racks were made of steel, as well as the ceiling supporting white painted steel beam structure. Both can be seen on Fig. 4.2. Integration to the surrounding equipment is not ideal, but as it is mainly cabling along the already existing cabling tracks, integration can be done quite easily.

### 4.2.3. Evaluation of manufacturing processes and materials

The new laboratory has less room than the existing structure requires. This means, that to use the same construction, the materials would have to be either reused and/or purchased, welded, machined and assembled. The uppermost equipment rack, on Fig. 4.2 on page 30, reaches almost to the ceiling level of the building, meaning the current layout is too high to be used in the the new premises because the concrete ceiling limits the maximum height. Steel structure is also dimensionally big, so the integration to the other equipment on the limited space would meet challenges.

### 4.2.4. Identification of concerns and deficiencies

Moving the beams in limited space, as well as support and install them using only manpower is a concern. Also installation of lifting devices is difficult and time consuming. Even though the beams would be made smaller in length, the steel structure would still be difficult to handle. Required flanges to connect the shorter beams together would increase the total weight of the frame beams even further.


Table 4.3.: Progress steps on the DFMA evaluation

### 4.3. Idea Matrix for options

### 4.3.1. Option 1

Idea was the maximal utilization of the design of the existing steel structure of the building, that supported also the equipment racks to attach to the support structure as well as the related adjustments of the equipment. Benefits include savings in costs of materials. Basic construction was available, engineering and additional materials required to relocate existing parts. Idea was to avoid material and equipment costs. Downsides was seen the heavy weight and large dimensions of the equipment. This would lead to handling and assembly problems in a limited space, with no cranes.

### 4.3.2. Option 2

Next option was to build the vertical structure from a lighter material. Aluminium profiles were selected, as similar profiles with different dimensions were already in use at the laboratory for some applications.Existing equipment would be utilized as much as possible.

### 4.3.3. Option 3

In this scope, all the construction for the support of equipment will be new. Both the vertical support and equipment racks as well as the support for the new vacuum chamber of the ion sources to be designed from aluminium profiles. Heavier and stiffer profile $45 \times 90 \mathrm{~mm}$ for the vertical support and vacuum chamber support and lighter $45 \times 45 \mathrm{~mm}$ profile for the equipment racks.

Table 4.4.: Idea Matrix
Idea Matrix to compare
different manufacturing options. *DFMA Basic Principles, Edward C. Lai \& Associates, [35].

| IDEA MATRIX for <br> - Vertical support <br> - Vacuum Chamber Support** <br> - Equipment racks <br> ITEM OF INTEREST | Option 1 <br> Existing construction \& materials | Option 2 Existing racks $\&$ new supports | $\begin{gathered} \text { Option } 3 \\ \text { New } \\ \text { construction } \\ \& \\ \text { materials } \end{gathered}$ | $\begin{gathered} \mathrm{N} \\ \mathrm{o} \\ \mathrm{t} \\ \mathrm{e} \end{gathered}$ |
| :---: | :---: | :---: | :---: | :---: |
| General: |  |  |  |  |
| material of equipment racks | steel | steel | aluminium |  |
| material of vertical supports | steel | aluminium | aluminium |  |
| mass of equipment rack | - | - | + |  |
| mass of vertical support | - | + | + |  |
| need for additional supports | - | - | - | ** |
| need for additional engineering | - | - | - | ** |
| need for new racks | + | + | - |  |
| costs for new racks | + | + | - |  |
| Needs of manufacturing: |  | existing/new |  |  |
| storing | - | -/+ | + |  |
| dismantling | - | -/+ | + |  |
| crane lifting \& handling | - | -/+ | + |  |
| cutting | - | -/- | - |  |
| welding | - | -/+ | + |  |
| grinding | - | -/+ | + |  |
| machining | - | -/+ | + |  |
| drilling | - | -/- | - |  |
| finishing | - | -/+ | + |  |
| painting | - | -/+ | + |  |
| Assembly: |  | existing/new |  |  |
| ease of assembly in difficult positions | - | -/+ | + |  |
| single hand held of part possible | - | -/+ | + |  |
| number \& types of parts used | - | -/+ | + | * |
| number and types of fasteners | - | -/+ | + | * |
| standardized level of parts \& finishes | - | -/+ | + | * |
| simple components | - | -/+ | + | * |
| need of site assy | + | +/- | - |  |
| one tool assembly | - | -/+ | + |  |
| modular parts | - | -/+ | + |  |
| modular subassemblies | - | -/+ | + | * |
| multifunctional parts | - | -/+ | + | * |
| minimized assembler movements | - | -/+ | + | * |
| self-locating features | - | -/+ | + | * |
| accessibility for tests and rework | - | -/+ | + | * |
| amount of operations \& process steps | - | -/+ | + | * |
| interchangable parts | - | -/+ | + |  |
| low cost post modifications | - | -/+ | + |  |
| Total number of positive factors | 2 | $3+25 / 2=16$ | 26 | 33 |

### 4.4. New construction

### 4.4.1. Brainstorming

A negative property of the original steel structure appeared to be the heavy weight. Laboratory room has plenty of equipment, electrical cabling and cabling racks, leaving only limited space for installation. As the supports were made of standard construction steel, mainly L-profile for heavily load applications, the supports became unnecessarily big in dimensions as well as heavy for the purpose in use.

Limited space handling of the big and heavy objects can cause problems during installation. Especially installation on a wall or on another vertical structure is challenging as the object needs to be supported over a period of time accurately to make the needed markings for holes or the actual attachment.

There is no crane in the room and building additional supports only for this installation would be difficult, time consuming and requiring special equipment for this purpose only. Manual installation on the other hand sets requirements to the size, weight and handling properties for the parts and equipment to be installed. It is an advantage, if the part can be held by only one hand, leaving another one for tools or for marking.Selecting a lighter material for the supporting construction would ease the installation process.
aluminium is well known for its lightweight properties, although the strength is not equal to steel. Selecting wall thickness and profile correctly, using aluminium it is possible to create constructions that can both stand remarkable loads and be easily manipulated due to the lightness. aluminium as a potential material lead to looking for the possibilities and advantages that an aluminium profile system already in use at the laboratory could offer for this application.

### 4.4.2. Design aspects

For the new construction, a profile system of aluminium was considered as a potential design. In manufacturability considerations the material is relatively flexible as it can be ordered as a bar stock or pre-machined according to manufacturing drawings. The delivery can include pre-drilled holes, special fasteners and all the other needed parts for wide range of applications. It is also possible to use stock bar and do the cut and machining in-house. The special fasteners of the aluminium system require holes of $\varnothing 17 \mathrm{~mm}$ which is a rare size on machining tools. It is available only as custom made and thus expensive. $\varnothing 17 \mathrm{~mm}$ drills are available in the workshop, but the slot on the aluminium profile causes the bare drill to yank, making drilling impossible without destroying the work piece. A drill guide tool that sets to the
end of profile to the correct distance, utilizes the slot of the aluminium profile to lock by two bolts for drilling, was developed. This prevents the excess vibration of the drill, enabling use of the drilling machine instead of more complicated and expensive machinery.

Drawings of the special tool, see the List of Assembly Drawings, section D.
Compatibility of the manufacturing processes is negligible except machining, as there is only need to attach the profiles to other surfaces or the equipment using the special fasteners of the system. Material re-saler is a domestic company and considered reliable on their deliveries. As the material is available in several standardized profiles, the risk for losing the profile from the market should be low. Instead, new supplementary profiles have been presented to widen the selection for the heavier, or lighter load applications. This profile system is already used widely at the IGISOL-laboratory and even on other equipments close to the vertical transfer line. A uniform look for the construction could be achieved if the vertical line support structures would be made using this profile system.

### 4.4.3. Manufacturing and Assembly aspects

Advantages of the aluminium in general, and the profile system under consideration:

- aluminium profile as a light material ease the assembly.
- Assembly needs no welding, parts are connected using a connector system with pre-drilled holes.
- Flexible profile or dimensions of an assembly can be modified by changing the individual parts.
- Manufacturing easy and costs low, only cutting and drilled holes for the connectors needed.
- Additional parts available for adjusting purposes, no need for engineering of special parts.
- Possibility to utilize the slots on the profile for adjusting the equipment.


### 4.4.4. Preliminary Layout for iteration

The first preliminary layout of the transfer line was created in the kick-off meeting held at the University of Jyvaskylä, Department of Physics. Basic limitations, like the maximum height of 3450 mm for the equipment of the vertical transfer line was
presented then and noted as one of the most important limitations for the engineering. Only some major components were noted, like the $90^{\circ}$ bender, quadrupoletriplet, diagnostic-box, two valves and two bellows to the ends of the line, one set just below the concrete ceiling and another set just before the $90^{\circ}$ bender. Preliminary layout, see Fig. 3.7.

### 4.5. DFMA Analyse Theory

Depending on the source, different number of guidelines are offered as DFA or DFMA principles for mechanical design. Boothroyd and Dewhurst [36] has eight guidelines and Edwards C. Lai \& Associates has eleven basic principles [35]. Ham \& Jeswiet [37] from the Queen's University are referring to Boothroyd \& Dewhurst on their lecture, but yet has eleven guidelines for DFA.

DFA guidelines by Boothroyd \& Dewhurst: [36]

1. Reduce part count and variations of parts
2. Attempt to eliminate adjustments
3. Design self-aligning and self-locating parts
4. Ensure easy access and unrestricted vision
5. Ensure ease of handling parts from bulk, tray etc.
6. Minimize the need for re-orientations during assembly
7. Design parts that cannot installed incorrectly
8. Maximize part symmetry if possible or make parts obviously asymmetrical

DFA guidelines by M. Ham \& J. Jeswiet [37]

1. Reduce number of parts
2. Reduce number of different parts - Standardize parts
3. Simplification of assembly
4. Reduction number of processes
5. Less fasteners especially screws \& bolts
6. Reduce tangling
7. Orientation
8. Critical orientation - obvious -see \& fit
9. Non-critical orientation - fit in any direction
10. Ensure access \& visibility
11. Easy part handling
12. Assemble from top
13. Reduce locating or alignment operations - manual or time consuming

DFMA Basic Principles by Edward C. Lai and Associates:

1. Minimize Part Count
2. Make Parts Multi-Functional
3. Reduce the Number of Screws and Screw Types
4. Facilitate Parts Handling
5. Use Standard Parts and Hardware
6. Encourage Modular Assembly
7. Use Stack Assemblies, Don't Fight Gravity
8. Design Parts with Self-Locating Features
9. Minimize Number of Surfaces
10. Assemble in the Open
11. Simplify and Optimize the Manufacturing Process
12. Eliminate Interfaces
13. Design for Part Interchangeability
14. Design Tolerances to Meet Process Capability

Principles of DFMA for electronics assembly were not followed in this study.

### 4.6. Systematic Iterative Design utilizing VDI-2221

Utilizing a systematic design tool, an engineering task is divided into seven separate stages. These seven stages are divided between four phases: clarification of the task, conceptual design, embodiment design and finally, detailed design. After reaching the next stage, iteration is done by going back to the previous stage with the information gained from the latter stage. The goals can be thus adjusted for better realization of the process through a learning curve.

Seven level iteration tasks and their expected results:

1. Defining the task-Specification
2. Determination of functions and their structure - Function structure
3. Search solution principles and their combinations - Principle solution
4. Divide into realizable modules - Module Structures
5. Develop layout of key modules - Preliminary layout
6. Complete overall layout - Definitive layouts
7. Prepare production and operation instructions - Product documents

In this study, the iteration tasks level 4: Dividing into realizable modules - Module Structures - and level 5: the Development of key modules - Preliminary layout - are combined to Modules of preliminary layout.

### 4.6.1. Transfer line for the test ion sources

The task is to design the transfer line to the laboratory for the test ion sources. This task is divided into two parts by the construction of the building: one meter thick concrete ceiling restricts the needed equipment in either the laboratory room, between main beam line level +1350 mm and ceiling +3450 mm or to the concrete roof above the room, that is +4450 mm from the floor level.

### 4.6.2. Determination of functions

Between the floor level and upper level is approximately 1 m long vacuum pipe, on a hole of 160 mm , drilled to the concrete ceiling and connecting the equipment on both 1st and 2nd floor. All the needed functions of the ion sources and vertical transfer line have to be placed over or below this vacuum pipe. This 1 m thick concrete ceiling prevents placing the ion-optical components in the ideal positions. As a smallest possible feed through, the pipeline is considered to be the least problematic in prevention of radiation from the radioactive premises to the low radiation area and thus defines the design.

Needed functions of the ion sources and transfer line:

1. Vacuum chamber for the ion sources
2. Quadrupole deflector for ion beam optics; turning the ion beam $90^{\circ}$
3. Equipment rack for the vacuum chamber
4. Support frame for the equipment rack and vacuum chamber
5. High voltage (HV) insulation between the equipment rack/vacuum chamber and support frame
6. Vacuum pump
7. DN160 HV insulation between the vacuum chamber and the vacuum pump
8. Pre-vacuum pump to improve the efficiency of the vacuum pump
9. Extraction element for the ion beam
10. DN100 HV insulation between the vacuum chamber and an extraction element
11. DN100 Gate valve to separate the test ion sources from the main beam line
12. Double-XY-element for ion beam optics
13. Quadrupole-triplet for ion beam optics
14. Diagnostic box
15. Vacuum pump for the diagnostic box
16. Pre-vacuum pump to improve the efficiency of the vacuum pump
17. Faraday cup and actuator to the flange of diagnostic box
18. Pirani vacuum gauge for rough to medium vacuum range to the diagnostic box
19. Penning vacuum gauge for lower vacuum range of the diagnostic box
20. Double-XY-element for ion beam optics
21. Wall support for the equipment between +1350 mm to +3450 mm .
22. DN100 gate valve to separate the vertical transfer line from the main beam line
23. $90^{\circ}$ bender to turn the test ion beam to the main beam line

### 4.6.3. Design options

The transfer line consists of several equipment with different requirements for their position in relation to the others.

1. All the equipment in one space: mechanically the most simple solution would be to place all the equipment on the floor level, between the levels +1350 and +3450 mm , leaving only the ion sources and other equipment that has to be close to the HV to the 2nd floor, above level +4450 mm . However, this solution has an ion-optical disadvantage.
2. Ideal solution: theoretically, due to the ion optics, the ideal solution is that the Quadrupole-triplet is positioned in the middle of the transfer line, i.e. between the quadrupole deflector and the inlet point of the $90^{\circ}$ bender. However it is not possible to place the quadrupole-triplet in the ideal position, as it would be partly inside the concrete ceiling. Opening the 160 mm diameter hole is not considered because this would mean a bigger risk for radiation coming from the main beam line from the 1st floor when running the accelerator.
3. Equipment separation: the quadrupole deflector is possible to place just below the ceiling, but this means that the DN100 gate valve and the double-XY above it had to be moved to the 2 nd floor, above level +4450 mm . For the efficient use of double-XY, best position would be immediately on the point where the ion beam leaves the ion sources. This way the corrective action can be done earlier, meaning lower energy needed for the transition.

### 4.6.4. Modules of preliminary layout: Ion Sources and Vertical Line

In this section, two iteration tasks levels of VDI-2221 on section 4.6, level 4 - Module Structures and level 5 - Preliminary layout - are combined to one.

Layout of the Ion source module consists of the functions 1-23 and additional parts like bellows to connect the module to the Vertical transfer line module. Layout can be seen on Fig. 4.3. Determination of functions, see 4.6.2.

- Ion source module consists of the functions 1-12 mentioned in Determination of functions.
- Vertical line module consists of the functions 13-21 mentioned in Determination of functions.


Figure 4.3.: Layout of the new laboratory. The ion source assembly and support are over the 1 meter thick concrete ceiling. The hole through ceiling for the test ion beam transfer line is on a one by one meter and 0,5 meter deep pit. The Vertical Line assembly below is on the radioactive area, including the $90^{\circ}$ bender and the related wall supports.

Layout of the Ion source module consists of the functions 1-12 (see section 4.6.2) and additional parts like bellows to connect the module to the Vertical transfer line module. The layout can be seen in Fig. 4.4.


Figure 4.4.: Assembly of the ion sources, pumps and a valve. HV insulators isolate the vacuum chamber from the pumps, extractor, valve and support frame that are grounded. The pipe with flanges for the pressure gages connects to the pipe below (not shown) coming through the concrete ceiling. Turbomolecular pump is the main pump, a scroll pump acts as a secondary pump. Ion sources shown are not actual, but only illustrate the relative positioning.

Layout of the Vertical transfer line consists of the functions 13-21 (see section 4.6.2) and additional parts like bellows to connect the module to the Ion source module. The layout can bee seen on Fig. 4.5.


Figure 4.5.: Assembly of the vertical line with the related equipment including quadrupole-triplet, diagnostic box, pumps, valves. Turbomolecular pump is the main pump, a scroll pump acts as a secondary pump. The pipe connecting the ion source to the transfer line is not shown.

### 4.6.5. Instructions for production and operation

For the purchase and assembly of the aluminium support system, as well as for the production and assembly of the various equipment engineered for the test ion source transfer line, manufacturing drawings and assembly drawings were produced. List of Assembly Drawings, see D on page 90. List of Manufacturing Drawings, see E on page 108.

As the power supply system, electrical controls and definition of operations will be defined, delivered and built later, operation instructions are excluded the systematic iterative design principles in this work.

### 4.7. Cost estimation

Due to the heavy construction designed originally to support the roof of the building, and only secondary to serve as an attaching platform for the vertical transfer line, the material consumption and therefore also the costs can be considered to be higher than for the lighter construction, that is designed only for the support function of the vertical transfer line. Steel profile is purchased $\mathrm{kg} / \mathrm{m}$ basis so the weight and costs will increase rapidly if the bigger profile is used.

The material costs of the aluminium vertical wall support and racks are calculated from the unit prices as the material was a part of a larger delivery. For this reason, the total sum was not available. The aluminium vacuum chamber support and rack support was ordered separately. The total sum of the invoice as well as the cost of vacuum chamber rack is presented.

The costs of in-house manufacturing of the steel structure was estimated by Research engineer Kimmo Ranttila [38] from the department of physics.

Table 4.5.: Cost calculation of the Transfer line supports and equipment racks, aluminium system

| aluminium system ITEMS | $\begin{aligned} & \mathrm{L} \\ & {[\mathrm{~m}]} \end{aligned}$ | pcs. | $\begin{array}{r} \text { Unit } \\ \text { price } \\ \text { no VAT } \\ € \end{array}$ | Total incl. VAT $22 \%$ $€$ |
| :---: | :---: | :---: | :---: | :---: |
| Vertical wall support and racks* |  |  |  |  |
| 45 x 90 L aluminium profile $\mathrm{L}=1500$ | 1,5 | 2 | 21,47 | 79,22 |
| $45 \times 90 \mathrm{~L}$ aluminium profile $\mathrm{L}=500$ | 0,5 | 8 | 21,47 | 105,63 |
| $45 \times 90 \mathrm{~L}$ aluminium profile $\mathrm{L}=290$ | 0,29 | 3 | 21,47 | 22,98 |
| $45 \times 45 \mathrm{~L}$ aluminium profile $\mathrm{L}=590$ | 0,59 | 2 | 10,23 | 14,85 |
| $45 \times 45 \mathrm{~L}$ aluminium profile $\mathrm{L}=500$ | 0,5 | 4 | 10,23 | 25,17 |
| $45 \times 45 \mathrm{~L}$ aluminium profile $\mathrm{L}=285$ | 0,285 | 2 | 10,23 | 7,17 |
| $45 \times 45 \mathrm{~L}$ aluminium profile $\mathrm{L}=250$ | 0,25 | 4 | 10,23 | 12,58 |
| Cutting of Al. profile series BSB-ISB |  | 25 | 0,50 | 15,38 |
| Drilling, hole $\varnothing 17 \mathrm{~mm}$ |  | 48 | 1,20 | 70,85 |
| Alu Connection Angle 90, $88 \times 88 \times 86$ |  | 8 | 4,90 | 48,22 |
| Cover Cap for Alu Connection Angle 90 |  | 8 | 1,14 | 10,96 |
| Central Connector, hammer $0^{\circ}$ |  | 16 | 2,50 | 49,20 |
| Central Connector, hammer $90^{\circ}$ |  | 8 | 2,48 | 24,40 |
| Cover Cap 90x45 for BSB2796 |  | 12 | 1,30 | 19,19 |
| Cover Cap 45x45 for BSB4569 |  | 12 | 0,56 | 8,27 |
| Roll-In T-slot Nut M6 with spring leaf |  | 26 | - | - |
| aluminium die-cast angle, left, 175x86x43mm |  | 2 | 7,17 | 17,64 |
| Total Costs, support and rack |  |  |  | 531,70 |
|  |  |  |  |  |
| Vacuum chamber support and rack: |  |  |  |  |
| $45 \times 45 \mathrm{~L}$ aluminium profile $\mathrm{L}=450$ | 0,45 | 2 | 10,23 | 11,32 |
| $45 \times 45 \mathrm{~L}$ aluminium profile $\mathrm{L}=130$ | 0,13 | 2 | 10,23 | 3,27 |
| Vacuum chamber support, aluminium |  |  |  | 637,30 |
| Vacuum chamber support, assembly |  | 4 | 45 | 221,40 |
| Total Costs, support and rack |  |  |  | 873,29 |

Table 4.6.: Cost estimation of the Transfer line supports and equipment racks, material:steel

Manufacturing in-house. Total sum includes VAT 23\%, Ranttila [38].

| ITEMS, steel structure <br> Estimated costs <br> Estimation of manpower and materials | hours | Unit <br> price <br> $€$ | Total <br> incl. <br> VAT <br> $€$ |
| :--- | :---: | :---: | ---: |
|  |  |  |  |
| Vertical wall support and racks, steel** |  |  |  |
| Engineering | 14 | 45 | 774,90 |
| Cutting | 7 | 45 | 387,45 |
| Welding | 21 | 45 | 1162,35 |
| Machining | 7 | 55 | 473,55 |
| Painting | 8 | 45 | 442,80 |
| Installation | 2 | 45 | 110,70 |
| Materials |  |  | 150,00 |
| Total |  |  | $\mathbf{3 5 0 1 , 7 5}$ |
|  |  |  |  |
| Vacuum chamber support, steel** | 2 | 45 | 110,70 |
| Cutting | 8 | 45 | 442,80 |
| Welding | 4 | 45 | 221,40 |
| Finishing and painting | 4 | 45 | 221,40 |
| Adjustment |  |  | 150,00 |
| Materials |  |  | $\mathbf{1 1 4 6 , 0 0}$ |
| Total |  |  |  |

### 4.8. Ion-optical simulations

Ion-optical simulations were used to study if an Einzel lens after the quadrupole deflector was required in order to transport the ion beam through the extractor before the beam scatters. First simulation was executed using the geometry of an existing Einzel lens construction and the reference simulation without it. Simulations showed a remarkable improvement was achieved when using the Einzel lens. For the vacuum chamber, the current construction appeared to be too long. A new, compact ion-optical equipment was designed and the geometry simulated. These simulations further showed the benefit of an Einzel lens in focusing of an ion beam.


Figure 4.6.: Ion beam and the positioning of the ion-optical elements in the simulation. Side view, $X-Y$ direction

Simulation was executed for the ion-optical equipment of the ion source unit, utilizing SIMION 8.1 Ion and Electron Optics Simulation software. The purpose of the simulation was to test the ion-optical properties of the intended dimensions and construction of the Einzel lens, extractor electrode and ground electrode with the existing Quadrupole deflector construction. Another aim was to find the start values for the voltage of the various ion-optical elements for the actual tuning of the Vertical Transfer Line.

Ion-optical simulation included an ion source, a Quadrupole deflector, an Einzel lens, an extractor and a ground electrode. A existing Quadrupole deflector simulation model along with different models of the Einzel lens and the extractor electrode, as well as different voltage values for the ion-optical elements were used. In each simulation, a group of ten particles were used to see the deviation of the particles
in-flight. The effects of each change of the beam was followed by observing the behaviour of the XY- and 3D views of the simulation run, XY cut shown in Fig. 4.6 and a 3D cut in Fig. 4.7.


Figure 4.7.: 3D-view of the ion beam formation and positioning of the ion-optical elements in the simulation.

The aim was to get all the particles of the simulated ion beam through the ionoptical elements. Voltage levels were adjusted to optimize the transport. Optimized voltages and levels can be seen in the chart of voltages in Table 4.7.

Table 4.7.: Voltage values of the ion-optical elements, compared to the ion source voltage +30 kV .

| ION-OPTICAL ELEMENT | Voltage [V] |
| :---: | :---: |
| Ion source |  |
| Ion extraction | -800 |
| quadrupole deflector |  |
| 1 | -800 |
| 2 | -800 |
| 3 Main electrode | 1100 |
| 4 Main electrode | -1800 |
| 5 | -800 |
| 6 | -800 |
| 7 | -350 |
| 8 | -850 |
| 9 | -800 |
| Einzel lens |  |
| Electrode 1 | -800 |
| Electrode 2 | -87 |
| Electrode 3 | -800 |
| double XY |  |
| $\emptyset 24 \mathrm{~mm}$ hole | -800 |
| Extractor electrode |  |
| $\emptyset 24 \mathrm{~mm} \mathrm{~L}=115$ | -20000 |
| Ground electrode |  |
| $\emptyset 24 \mathrm{~mm} \mathrm{~L}=20$ | -30000 |



Figure 4.8.: Potential energy level variation of the ion beam in simulation.

The cross section of the ion beam simulation shows the deviation of the particles. An ideal situation would be a uniform, tightly focused circle spot. The deviation can be seen in figure 4.9.


Figure 4.9.: Particle deviation of the ion beam in the simulation.

### 4.9. New ion-optical equipment

The preliminary layout of the Vertical Transfer Line did not include the Einzel lens, as it was considered that the ion beam optics could be adjusted adequately utilizing the previously used equipment. Using the focusing elements of the quadrupole deflector, both for the incoming beam and for the exiting beam, was not adequate to focus the beam sufficiently into the extractor in a tight bunch. Neither did the adjusting of the main electrodes and shim electrodes lead to an improvement in the beam direction, and to reflect the beam as a uniform group. In simulations, without an Einzel lens, the beam scattered before entering the extractor electrode.

In the first simulations with an Einzel lens, a geometry of an existing design ( $>100$ mm ) was used. With the Einzel lens positioned just after the quadrupole deflector, tighter grouping of ions during flight was noticed. Later, a new, compact design was simulated. The phenomenon existed, regardless of the length of the Einzel lens electrode rings. In the simulation, both the short and the long electrode rings of the Einzel lens improved the focus of the ion beam. Assembly of the compact Einzel lens can be seen in an assembly drawing in section D. Detailed drawings can be found from the List of Manufacturing Drawings in section E.

Simulation results supported placing the Einzel lens after the Quadrupole deflector. The limited space of the 6 -way vacuum chamber lead to integrating a compact Einzel lens with the double XY electrode as seen in Fig. 4.10.


Figure 4.10.: Assembly of the ion-optical equipment: quadrupole deflector, Einzel lens, double $X Y$, extractor and ground electrode, positioned as in the ion-optical simulations. An Einzel lens and double XY are integrated to fit the equipment inside the 6-way vacuum chamber and to simplify the alignment of the various components. Extractor and ground electrode are placed into a common vacuum chamber with isolated power supplies.

A short HV-isolator was designed to fit on the flange of the 6 -way vacuum chamber to enable the connection of a new, small diameter extractor and a ground electrode construction. Due to the HV potential difference, the distance between the tip of the extractor and the double XY has to be approximately 30 mm . To reach this dimension, the extractor has to be installed partly inside the HV insulator, see cross section Fig. 4.11. The extractor and the ground electrode are also integrated into a common vacuum chamber with isolated power supplies. Short dimensions simplify the alignment of the optical elements. Alignment is important because it affects the beam trajectory in a similar way as adjustment of the voltage of the elements. Earlier, the alignment has been done using a laser and a cross hair on
the vacuum pipelines and flanges. This is a time consuming process that requires accuracy. By integrating the Einzel lens and a double XY with the machined parts one alignment procedure can be eliminated. Using a special tool for the centering of the quadrupole deflector to the 6 -way vacuum chamber pipes, the components can be aligned. Alignment does not require the installation of the 6 -way vacuum chamber to the aluminium supports. After installing the HV insulator, the extractor electrode is considered to be aligned using a $\emptyset 24 \mathrm{~mm}$ diameter tool (Drawing on page 113), that is an exact fit with the electrode rings of the extractor electrode, ground electrode and with the end plates of the double XY.


Figure 4.11.: Cross section of the 6 -way vacuum chamber with the ion-optical equipment installed, showing the ion-optical elements: a quadrupole deflector, an Einzel lens, double XY, extractor and ground electrode. The ion source has the same voltage as the HV source. The Einzel lens and double XY are integrated to fit inside the 6-way vacuum chamber and to ease the alignment of the various components.

### 4.9.1. HV insulator's dielectric breakdown distance

Due to the high voltage of 30 kV between the double XY in the 6 -way vacuum chamber and extractor electrode, a HV insulator is required. For a rigid construction, the length of the HV insulator should be as short as possible. HV sets limitations to this distance due to the risk for a dielectric breakdown. Dielectric breakdown causes permanent changes in appearance and properties on an insulation material.

For the new construction of the ion-optical components, an order of 100 mm long HV insulation was desirable. The existing HV insulator design available was 200 mm in length and was seen difficult to be installed because of its' length and to be used with the new equipment.

Another already proven HV insulator design is in use on the main beam line of the accelerator laboratory. The design is horizontally installed, 100 mm long and 300 mm in diameter, but was considered too big and heavy for the new vertical position. This $\emptyset 300 \mathrm{~mm}$ HV insulator was selected as the reference for the calculation to define the distance against the dielectric breakdown. This reference HV insulator was designed using criteria for both vacuum and atmospheric pressure. For a vacuum, 1 mm was used as equal to a voltage of 1 kV and in atmospheric pressure, 10 mm was used as equal to 1 kV in calculation of the minimum dielectric breakdown distance. Thus, the voltage of 30 kV requires a minimum dielectric breakdown distance of 300 mm in atmospheric pressure and in vacuum, 30 mm , respectively. [39].

The dielectric breakdown distance is calculated along the outer surface of the HV insulator. The surface of the HV insulator has a corrugated shape, having a certain number of ridges and furrows. A spreadsheet was created for the iteration process to select the design of the different combinations of length and number of ridges. Then optimization was continued selecting the outer- and inner diameters.

For the calculation, the maximum and minimum diameter of the insulating material, the length of the HV insulator and the number of the ridges were given as variables. The outer diameter of the metal flanges used for connecting the HV insulator to the vacuum system was also given, to deduct the impact of the stainless steel as a conductive material. As a result, the distance for dielectric breakdown between the metal flanges was calculated. This distance was then compared with the distance of the existing reference design, presented in Table 4.8.

Table 4.8.: Dielectric breakdown distance calculation of the HV insulator. The dielectric breakdown distance for the new construction is required to exceed the 342 mm of the reference HV insulator. Dimensions of the new design can be seen in a manufacturing drawing KR3-A059 on page 110.

|  | Reference <br> Ø300 <br> Design <br> $[m m]$ | New <br> (260 <br> Design <br> $[\mathrm{mm}]$ |
| :--- | ---: | ---: |
| DIMENSIONS OF THE ITEM |  |  |
| Required dielectric breakdown distance | $\mathbf{3 4 2}$ | $\mathbf{3 5 2}$ |
| Calculated distance of diselectric breakdown | 25 |  |
| Measured thickness of the ridge |  | 20 |
| Calculated thickness of the ridge | 100 |  |
| Measured length of the insulator |  | 100 |
| Given length of the insulator | $\varnothing 300$ | $\varnothing 260$ |
| Maximum diameter of the insulator, ridge | $\varnothing 200$ | $\varnothing 160$ |
| Minimum diameter of the insulator, furrow | $\varnothing 165$ | $\varnothing 165$ |
| Flange diameter on HV-side | $\varnothing 165$ | $\varnothing 165$ |
| Flange diameter on grounded side | $\varnothing 100$ | $\varnothing 100$ |
| Inside diameter of the insulator | $[p c s]$. | $[p c s]$. |
|  | 2 | 3 |
| Number of ridges |  |  |

The dielectric breakdown distance for the new construction is required to exceed the 342 mm of the reference HV insulator. The distance is measured between the edges of the connecting stainless steel flanges on the HV-side and grounded side. The dielectric breakdown distance of the new design is 352 mm , exceeding the reference dimension by 10 mm . Dimensions of the new design of the HV insulator can be seen in a manufacturing drawing KR3-A059 on page 110.

After engineering, the dielectric breakdown distance of the selected design was confirmed from the assembly drawing of the HV insulator, shown in Fig. 4.12.


Dielectric breakdown distance from HV-flange to grounded flange:

| $2 \times 37,5$ | $=75 \mathrm{~mm}$ |
| :--- | ---: |
| $5 \times R 10 \times \Pi=$ | 157 mm |
| $4 \times 30$ | $=120 \mathrm{~mm}$ |
| Distance: | 352 mm |

Figure 4.12.: Dimensions of the $H V$ insulator for the dielectric breakdown distance calculation. Calculation is done along the outer surface of the HV insulator between the edges of the connecting flanges on the $H V$ side and grounded side.

### 4.10. Final layout

The final layout contains both the new design of the aluminium support system utilizing the systematic design tools DFMA and VDI-2221 and the new ion-optical equipment, designed on the basis of ion-optical simulations. Test ion source assembly can be seen in section $D$ and the manufacturing drawings section E. Master assembly of the Vertical Transfer Line, ion sources and their supports can be seen in Fig. 4.13.

Vertical wall support assembly on the 1st floor includes items 1-15:

1. $90^{\circ}$ bender
2. Floor support for $90^{\circ}$ bender
3. Two gate valves
4. Wall support
5. Equipment racks for quadrupole-triplet and diagnostic box
6. Quadrupole-triplet
7. Diagnostic box
8. Turbomolecular pump Edwards STP-301
9. Scroll pump Edwards XDS 10
10. Faraday cup and the actuator assembly, not presented
11. double XY
12. Bellows
13. Two intermediate pipes
14. Two pressure gauges for diagnostic box, not presented
15. Connecting pipe for 2 nd floor

Ion source assembly on the 2nd floor includes items 16-32:
16. Ion source support
17. 6 -way vacuum chamber for the test ion sources
18. Equipment rack for the 6 -way vacuum chamber
19. HV insulator for Turbomolecular pump
20. HV insulators between 6 -way chamber and the Ion source support
21. Turbomolecular pump Edwards STP-301
22. Support for the turbomolecular pump
23. Scroll pump Edwards XDS 10
24. Stand for the scroll pump
25. Quadrupole deflector
26. Double XY
27. Einzel lens
28. Extractor electrode
29. Ground electrode
30. HV insulator for extractor- and ground elecrode assembly
31. Gate valve, VAT
32. Support for VAT gate valve, not presented.
33. Intermediate pipe with connections for pressure gauges
34. Bellows
35. Blank flanges for optional connections


Figure 4.13.: Layout of the ion sources, related HV isolators and the pipe connecting the Vertical transfer line through the concrete ceiling. Laser ion source is presented as an example of an optional future ion source only to illustrate different positions for the ion sources.

## 5. RESULTS

A test ion beam can be produced without the use of an accelerator. Following the ALARA principle, improvement was achieved with respect to the radioactive exposure during the operation with the test ion sources.

The new construction enables:

- To switch between on-line and off-line ion beams without entering the radioactive area.
- Reduce the time between on-line and off-line ion beams by avoiding the cooling time of typically one week with light ion beams.
- Avoiding the dosage of radioactive background radiation after light ion beam runs by re-locating the manual off-line ion source out of the radioactive area to a non-active area.
- Mass separation of the test ions.
- Multiple stationary test ion sources available for test runs, not requiring any dismantling of previous ion source and installation of new one.
- Switch from one off-line ion source to another off-line ion source can be done without entering the radioactive area.

The construction of the Vertical Transfer Line is presented in the layout of the laboratory in Fig. 5.1.

### 5.1. Results of simulations

The ion-optical simulations showed that an Einzel lens after the quadrupole-deflector was required to transport the ion beam through the extractor electrode. New, compact ion-optical equipment was designed, based on the simulations.

- 50 mm long Einzel lens was designed to enable it to be placed after the quadrupole deflector. The Einzel lens was also designed to be integrated with the double XY deflector.
- A new, small diameter extractor electrode and holders were designed to fit into a DN100 vacuum line.
- Short extractor and the position of the compact double XY deflector required designing a short HV insulator. A 100 mm long HV-insulator was developed.


Figure 5.1.: Layout of the IGISOL laboratory,including the Vertical Transfer Line.

### 5.2. Results utilizing DFMA

- Aluminum beams for the supports and equipment racks can be assembled to each other using only one tool, a hex key.
- The heaviest individual aluminum system part weighs $4,6 \mathrm{~kg}$. The weight of the frame of the wall support assembly to be installed manually to the concrete wall weighs $12,2 \mathrm{~kg}$ total.
- Assembly time for the vacuum chamber rack was 4 hours.
- Assembly time for the vertical support was 16 hours.
- Alignment of the equipment does not require any separate adjustment screws or other additional construction. The horizontal alignment is done by moving the equipment rack in relation to the support arms of the vertical rack. Vertical positioning of the equipment is done by moving and tightening the support arms to the specified position on the vertical wall support 45x90-profile beams.
- Modification of the dimensions of the assembly is flexible due to the interchangeable parts.
- Cost comparison of vertical wall support and racks: total costs of utilizing different materials: aluminum $€ 468.18$, versus steel $€ 3501.75$, difference in advantage of aluminum system $€ 3033.57$.
- Cost comparison of vacuum chamber support between two different materials: aluminum system $€ 873.29$ versus steel, $€ 1146.00$. Difference in advantage of aluminum system €272.71.
- Total cost difference in advantage of the aluminum system $€ 3242.76$, aluminum system, Table 4.5 and steel, Table 4.6.


## 6. DISCUSSION

The switch between on-line and off-line ion beams as well as between on-line to off-line ion sources has required an entry to the radioactive area. After the light ion source runs, the premises remain radioactive, requiring approximately cooling time of one week before entering the area and manually handling the ion sources.

Producing the test ion beam outside the radioactive area of the accelerator's main beam line lowers the exposure to radioactive radiation towards the personnel working on the test ion sources by eliminating the entry and working time in at the radioactive area. Avoiding the cooling time of the radioactive premises enables the start of new test ion runs earlier. The aim of ALARA principle is to lower the dosage of radioactive radiation. This can thus be followed.

Having multiple test ion sources, each installed to the 6 -way cross vacuum chamber and positioned outside the radioactive area, speeds up the process switching the test ion source between the runs as there is no need for mechanical dismantling and/or assembly. The new layout makes possible mass separation of the test ions as the vertical line is placed before the dipole magnet.

Positioning the Einzel lens and double XY deflector immediately after the quadrupole deflector was seen as most economic way to control the beam. After the ion source and quadrupole deflector, the energy of the beam is relatively modest, meaning that the voltage required for control of the beam can be lower. To study this layout, simulations were performed.

Ion-optical simulations showed the need of an Einzel lens after the quadrupole deflector in order to transport the ion beam through the extractor. A new, compact ion-optical equipment was designed, based on these simulations. As the equipment is not yet installed, there are no test ion beam runs to confirm the results of the simulations. After the installation of the Vertical Transfer Line, the actual results can be compared to the simulations.

In addition, a new extractor for a smaller diameter vacuum pipe was designed. The existing extractors were designed solely for the bigger diameter vacuum line and would have limited the vacuum pumping capacity in a smaller diameter line. The layout of the equipment; quadrupole deflector. followed by the einzel lens integrated with the double XY deflector, and assembly of extractor electrode and ground electrode was a result of the aim towards a compact design, according to
the ideal situation. Since there is a 1 meter-thick concrete ceiling limiting the positioning of the equipment of the Vertical Transfer Line, the long transfer to the next ion-optical equipments below the ceiling may prove to be problematic due to the scattering of the ion beam. The beam may scatter before entering the quadrupole-triplet, causing reduction in transport efficiency. In the line, however, there are intermediate parts that can be re-positioned. If needed, the extractor- and ground electrodes, either both or the ground electrode only, can be placed lower, even under the 1 meter ceiling and replaced with a bellows or pipe of the same length of 120 mm . This way, the extraction length can be extended thus diminishing the scattering effect before the next ion-optical element in the vacuum line.

Mass separation of the test ions is possible due to the location of the test ion sources. As the ion source is before the bending magnet, the test ions will be mass separated.

Ion-optical simulations gave the impression of a functional ion-optical layout. In reality, the equipment seldom performs as good as in the simulations. The unknown factors may lower the performance.

Vacuum level is a concern when producing an ion beam as the uniformity of the beam depends on the vacuum. In this case, the vacuum pumps, their positioning and the design of the ion-optical equipment is essential. In the vacuum line, there should be sufficient pumping capacity.

In this study, the aim is to gain a control sample for calibration without the use of a cyclotron. Equipment to be calibrated by using the off-line ion source would be all the ion optics between the ion source and the Penning trap, as well as the extraction of Penning trap.

In this thesis, an electric discharge ion source is considered as a main test ion source. An optional secondary ion source was Carbon Clusters. The third position in the 6 -way vacuum chamber is for any other future option.

If DFMA would not have been used, a remarkable number of advantages and disadvantages of the different options of the construction might have been unnoticed. DFMA analysis led to a systematic comparison of the problem and to concentrate on a more detailed level thus enabling a widening of the range of issues related to improvement of the current construction.

In this study, the DFMA forms DFMA1 and DFMA2 may not have been utilized in their full potential. DFMA1 was used to evaluate the existing complete dismantled steel construction. The aluminium construction and equipment was placed to a new location, so the surroundings were not equal. The difficulty with DFMA1 is to define which of the violations against the manufacturability are characteristic only for the supports and which are for the equipment or is it a combination of both.

DFMA1 forms, see section A on page 72.
DFMA2 forms were used to evaluate the ergonomics on assembly of the new aluminum system. Under evaluation was the separate parts including wall support, support frame of the ion sources, equipment racks of diagnostic box, quadrupole triplet, vacuum chamber and the assemblies of the above mentioned; vertical section 1st floor and ion source assembly 2nd floor. DFMA2 forms, see section B. DFMA2 forms may give an over optimistic impression of the assembly as there is only one or two violations against 21 DFMA principles in total. If the place of assembly is clean, level and there is room to unpack the parts in good order, the assembly of the separate beam elements is easy. Especially, any perpendicular feature in addition to a level surface will make the assemby quicker. In this case, it is easy to pre-tighten the hexagon-screws, position the profiles and make the final tightening. Assemblies of order 0.5 m by 1 m can be handled manually. If the working place is not even, it makes the assembly more demanding in the early phase, as then it may require to both hands for the alignment of two different profiles at the same time, preventing simultaneous holding and tightening of the connector's screw. Also dirt may cause difficulties in this application, possibly turning the connector head wrong way in the slot, preventing the locking and slowing down the assembly. Durability against dirt, however, was not mentioned as a violation against the DFMA principles.

In this thesis, some of the DFMA main principles were utilized including:

- Minimize number of parts.
- Minimize manufacturing phases
- Minimize tools used

This led to construction that requires only two different aluminum profiles, cutting, drilling and one tool for the assembly. Attaching the equipment such as the diagnostic box required three holes per profile, six altogether for the M8 bolts and an additional M13 wrench. It can be considered relatively simple in terms of construction manufacturability and assembly.

- Requires only two different aluminum profiles
- Only cutting is needed to manufacture a part
- Drilling holes for the connectors, for $45 \times 45$ one hole/joint and for $45 \times 90$ profile two holes/joint
- One tool for the assembly
- Light parts to install

The mass of the bigger profile, 45 x 90 is $3.1 \mathrm{~kg} / \mathrm{m}$. The heaviest separate
aluminum part was the beam of the vertical wall support; 4.6 kg . The weight of the wall support assembly consist of two of these beams and three connection beams weighs a total of 12.2 kg . This is well below the recommendation of ILO, International Labour Organization, the Maximum Permissible Weight to Be Carried by One Worker Recommendation R128; temporary lifts 55 kg , continuous lifts 35 kg for men and for women 30 kg and 20 kg accordingly [40, 41].

## 7. CONCLUSIONS

DFMA was used to design the Vertical Transfer Line. ALARA principle was followed and the resulting risk to exposure of radioactivity is reduced. This has been achieved by relocating the reference ion sources to a non-hazardous area.

Current design allows the flexible modifications or addition of new equipment, especially the area around the ion sources. Also modifications of the supporting structure are simple, dismantling is easy and material costs are low. Use of DFMA eased to evaluate the different technical solutions and lead to a low cost structure. Method, however, would be more beneficiary for serial production.

Emphasis for the future research projects could be re-engineering of the current $90^{\circ}$ bender. The existing design currently has no capacity to bend the HV beams. Secondly, the installation of the existing discharge ion source, as well as the design of a carbon cluster ion source is required. Utilizing laser technology for this ion source unit is not currently planned, but could be included in a long term development program at the Department of Physics. The unit has been designed so that a laser beam can be relatively easily directed into the ion source.

## A. DFMA1 manufacturability forms

DFMA1 forms are used to evaluate how user friendly the construction is to manufacture. The ease of manufacturing was measured by the number of different stages and parts required for finished product.

List of DFMA1 manufacturability forms:

- Main assembly, page 73
- Test Ion source unit, page 74
- Wall rack, page 75
- Diagnostic box, page 76




| DFMA 1 <br> Ergonomics in Design for Manufa |  |  |  |  |  |  |  |  |  |  |  |  |  |  |  |  |  |  |  |  |  |  |  |  |
| :---: | :---: | :---: | :---: | :---: | :---: | :---: | :---: | :---: | :---: | :---: | :---: | :---: | :---: | :---: | :---: | :---: | :---: | :---: | :---: | :---: | :---: | :---: | :---: | :---: |
| Product name: <br> Vertical Transfer Line |  |  |  |  |  |  |  |  |  |  |  |  | Author: |  |  |  |  |  |  |  |  |  |  |  |
|  |  |  |  |  |  |  |  |  |  |  |  |  | Kari Rytkönen |  |  |  |  |  |  |  |  |  |  |  |
| Instructions: <br> 1. List the parts in design order they are assembled. <br> 2.Note the design rules that are violated for each step. <br> 3. Mark each of the violating boxes with " 1 " and the score will be automatically calculated to "SCORE/ITEM" and "OVERALL SCORE" sells. <br> Color tells the level of coplexity of assembly: <br> RED= complex, <br> YELLOW= average <br> GREEN = easy |  |  |  |  |  |  |  |  |  |  |  |  |  |  |  |  |  |  |  |  |  |  |  |  |
| Item | SUBASSEMBLY 3, DIAGNOSTIC BOX |  |  |  |  |  |  |  |  |  |  |  |  |  |  |  |  |  |  |  |  |  |  |  |
| no. | Part / Assembly |  |  |  |  |  |  |  |  |  |  |  |  |  |  |  |  |  |  |  |  |  |  |  |
| 1 | Vacuum Chamber | 1 | 1 | 1 | 1 |  |  |  |  | 1 |  |  | 1 | 1 | 1 |  | 1 |  | 1 |  |  | 1 | 1 | 12 |
| 2 | FC-Cup assembly | 1 | 1 |  | 1 |  |  |  |  | 1 |  |  | 1 | 1 | 1 |  | 1 |  | 1 |  |  | 1 | 1 | 11 |
| 3 | Bellow tube | 1 |  | 1 | 1 |  |  |  |  | 1 |  | 1 | 1 |  |  |  |  |  | 1 |  |  | 1 |  | 8 |
| 4 | Prepump Edwards XDS-10 | 1 | 1 | 1 | 1 |  |  |  |  | 1 |  |  | 1 | 1 |  |  | 1 |  | 1 |  |  | 1 | 1 | 11 |
| 5 | Turbomolecular pump Edwards | 1 | 1 | 1 | 1 |  |  |  |  | 1 |  |  | 1 | 1 |  |  | 1 |  | 1 |  |  | 1 | 1 | 11 |
| 6 | Connector | 1 |  |  |  |  |  |  |  |  |  | 1 |  |  |  |  | 1 |  | 1 |  |  | 1 |  | 5 |
| 7 |  |  |  |  |  |  |  |  |  |  |  |  |  |  |  |  |  |  |  |  |  |  |  | 0 |
| 8 |  |  |  |  |  |  |  |  |  |  |  |  |  |  |  |  |  |  |  |  |  |  |  | 0 |
| 9 |  |  |  |  |  |  |  |  |  |  |  |  |  |  |  |  |  |  |  |  |  |  |  | 0 |
| 10 |  |  |  |  |  |  |  |  |  |  |  |  |  |  |  |  |  |  |  |  |  |  |  | 0 |
| 11 |  |  |  |  |  |  |  |  |  |  |  |  |  |  |  |  |  |  |  |  |  |  |  | 0 |
| 12 |  |  |  |  |  |  |  |  |  |  |  |  |  |  |  |  |  |  |  |  |  |  |  | 0 |
| 13 |  |  |  |  |  |  |  |  |  |  |  |  |  |  |  |  |  |  |  |  |  |  |  | 0 |
| 14 |  |  |  |  |  |  |  |  |  |  |  |  |  |  |  |  |  |  |  |  |  |  |  | 0 |
| 15 |  |  |  |  |  |  |  |  |  |  |  |  |  |  |  |  |  |  |  |  |  |  |  | 0 |
| 16 |  |  |  |  |  |  |  |  |  |  |  |  |  |  |  |  |  |  |  |  |  |  |  | 0 |
| 17 |  |  |  |  |  |  |  |  |  |  |  |  |  |  |  |  |  |  |  |  |  |  |  | 0 |
| 18 |  |  |  |  |  |  |  |  |  |  |  |  |  |  |  | Acc | ess p | orts | and | est p | points not | labe | led | 0 |
| 19 |  |  |  |  |  |  |  |  |  |  |  |  |  |  |  | Diffic | ult | ccess | to | ey m | maintenan | ce ar | eas | 0 |
| 20 |  |  |  |  |  |  |  |  |  |  |  |  |  |  |  |  |  | not | see | displa | ay while a | djus | ting | 0 |
|  |  |  |  |  |  |  |  |  |  |  |  |  |  |  |  |  |  |  |  |  | OVERAL | SCO |  | 58 |

## B. DFMA2 ergonomics forms

DFMA2 forms are used to find solution to the problematic issues found on assembly and manufacturing.

List of DFMA2 ergonomics forms:

- Wall Support, page 78
- Support frame, page 79
- Vertical section 1st floor, page 80
- Ion source assembly, 2nd floor, page 81
- Rack / Diagnostic box, page 82
- Rack / Vacuum chamber, page 83
- Rack / Quadrupole triplet, page 84


## Ergonomics in DFMA Problem Solving Form

Use this form to identify opportunities for improvement in the product design process

1) Check the design principle is violated
2) Note the specific part that could be improved
3) Briefly note the anticipated improvement
4) Use the form on the reverse side / following page to more develop the recommendations.

Product name: | Vertical transfer line | Name: Wall support |
| :--- | :--- |
|  | Date: 15.8 .2012 |

| DFMA Principle | Violation | Part | Anticipated improvement |
| :--- | :--- | :--- | :--- |
| Design for stable base |  |  |  |
| Minimize reorientation |  |  |  |
| Insertion point easy to see and reach |  |  |  |
| Decrease need for specialized fixtures |  |  |  |
| Insertion of parts | V |  |  |
| Decrease ambiguity in part/subassembly orientation |  |  |  |
| Design parts with self locking features |  |  |  |
| Fail-safe Assembly |  |  |  |
| Minimize part count/levels of assembly |  |  |  |
| Minimize levels of assembly |  |  |  |
| Minimize number/types of fasteners, cables, etc. |  |  |  |
| Modular, interchangeable assemblies |  |  |  |
| Self-fastening features |  |  |  |
| Use unique characteristics of the material |  |  |  |
| Built-in springs |  |  |  |
| Pressed or molded parts |  |  |  |
| Injection-molded buttons or signs |  |  |  |
| Ergonomics Applications |  |  |  |
| Ease of Handling |  |  |  |
| Correct tool |  |  |  |
| Eliminate special tools |  |  |  |
| Avoid "washrag" postures |  |  |  |
| Comfort zone |  |  |  |
|  |  |  |  |

## Ergonomics in DFMA Problem Solving Form

Use this form to identify opportunities for improvement in the product design process

1) Check the design principle is violated
2) Note the specific part that could be improved
3) Briefly note the anticipated improvement
4) Use the form on the reverse side / following page to more develop the recommendations.

Product name: | Vertical transfer line | Name: Support frame / Ion Sources |
| :--- | :--- |
|  | Date: 15.8 .2012 |

| DFMA Principle | Violation | Part | Anticipated improvement |
| :--- | :--- | :--- | :--- |
| Design for stable base |  |  |  |
| Minimize reorientation |  |  |  |
| Insertion point easy to see and reach |  |  |  |
| Decrease need for specialized fixtures |  |  |  |
| Insertion of parts |  |  |  |
| Decrease ambiguity in part/subassembly orientation |  |  |  |
| Design parts with self locking features |  |  |  |
| Fail-safe Assembly |  |  |  |
| Minimize part count/levels of assembly |  |  |  |
| Minimize levels of assembly |  |  |  |
| Minimize number/types of fasteners, cables, etc. |  |  |  |
| Modular, interchangeable assemblies |  |  |  |
| Self-fastening features |  |  |  |
| Use unique characteristics of the material |  |  |  |
| Built-in springs |  |  |  |
| Pressed or molded parts |  |  |  |
| Injection-molded buttons or signs |  |  |  |
| Ergonomics Applications |  |  |  |
| Ease of Handling |  |  |  |
| Correct tool |  |  |  |
| Eliminate special tools |  |  |  |
| Avoid "washrag" postures |  |  |  |
| Elinate mechanical pressure |  |  |  |
|  |  |  |  |

## Ergonomics in DFMA Problem Solving Form

Use this form to identify opportunities for improvement in the product design process

1) Check the design principle is violated
2) Note the specific part that could be improved
3) Briefly note the anticipated improvement
4) Use the form on the reverse side / following page to more develop the recommendations.

Product name: | Vertical transfer line | Name: Vertical section, 1st floor | Date: 15.8 .2012 |
| :--- | :--- | :--- |

| DFMA Principle | Violation | Part | Anticipated improvement |
| :--- | :--- | :--- | :--- |
| Design for stable base |  |  |  |
| Minimize reorientation |  |  |  |
| Insertion point easy to see and reach |  |  |  |
| Decrease need for specialized fixtures |  |  |  |
| Insertion of parts | V |  |  |
| Decrease ambiguity in part/subassembly orientation |  |  |  |
| Design parts with self locking features |  |  |  |
| Fail-safe Assembly |  |  |  |
| Minimize part count/levels of assembly |  |  |  |
| Minimize levels of assembly |  |  |  |
| Minimize number/types of fasteners, cables, etc. |  |  |  |
| Modular, interchangeable assemblies |  |  |  |
| Self-fastening features |  |  |  |
| Use unique characteristics of the material |  |  |  |
| Built-in springs |  |  |  |
| Pressed or molded parts |  |  |  |
| Injection-molded buttons or signs |  |  |  |
| Ergonomics Applications |  |  |  |
| Ease of Handling |  |  |  |
| Correct tool |  |  |  |
| Eliminate special tools |  |  |  |
| Avoid "washrag" postures |  |  |  |
| Comfort zone |  |  |  |
|  |  |  |  |

## Ergonomics in DFMA Problem Solving Form

Use this form to identify opportunities for improvement in the product design process

1) Check the design principle is violated
2) Note the specific part that could be improved
3) Briefly note the anticipated improvement
4) Use the form on the reverse side / following page to more develop the recommendations.

Product name: Vertical transfer line Name: Ion source assy, 2nd floor $\quad$ Date: | 15.8 .2012 |
| :--- | :--- |

| DFMA Principle | Violation | Part | Anticipated improvement |
| :--- | :--- | :--- | :--- |
| Design for stable base |  |  |  |
| Minimize reorientation |  |  |  |
| Insertion point easy to see and reach |  |  |  |
| Decrease need for specialized fixtures |  |  |  |
| Insertion of parts | V |  |  |
| Decrease ambiguity in part/subassembly orientation |  |  |  |
| Design parts with self locking features |  |  |  |
| Fail-safe Assembly |  |  |  |
| Minimize part count/levels of assembly |  |  |  |
| Minimize levels of assembly |  |  |  |
| Minimize number/types of fasteners, cables, etc. |  |  |  |
| Modular, interchangeable assemblies |  |  |  |
| Self-fastening features |  |  |  |
| Use unique characteristics of the material |  |  |  |
| Built-in springs |  |  |  |
| Pressed or molded parts |  |  |  |
| Injection-molded buttons or signs |  |  |  |
| Ergonomics Applications |  |  |  |
| Ease of Handling |  |  |  |
| Correct tool |  |  |  |
| Eliminate special tools |  |  |  |
| Avoid "washrag" postures |  |  |  |
| Eomfort zone |  |  |  |
|  |  |  |  |

## Ergonomics in DFMA Problem Solving Form

Use this form to identify opportunities for improvement in the product design process

1) Check the design principle is violated
2) Note the specific part that could be improved
3) Briefly note the anticipated improvement
4) Use the form on the reverse side / following page to more develop the recommendations.

Product name: | Vertical transfer line | Name: Rack / Diagnostic box | Date: 15.8 .2012 |
| :--- | :--- | :--- |

| DFMA Principle | Violation | Part | Anticipated improvement |
| :--- | :--- | :--- | :--- |
| Design for stable base |  |  |  |
| Minimize reorientation |  |  |  |
| Insertion point easy to see and reach |  |  |  |
| Decrease need for specialized fixtures |  |  |  |
| Insertion of parts |  |  |  |
| Decrease ambiguity in part/subassembly orientation |  |  |  |
| Design parts with self locking features |  |  |  |
| Fail-safe Assembly |  |  |  |
| Minimize part count/levels of assembly |  |  |  |
| Minimize levels of assembly |  |  |  |
| Minimize number/types of fasteners, cables, etc. |  |  |  |
| Modular, interchangeable assemblies |  |  |  |
| Self-fastening features |  |  |  |
| Use unique characteristics of the material |  |  |  |
| Built-in springs |  |  |  |
| Pressed or molded parts |  |  |  |
| Injection-molded buttons or signs |  |  |  |
| Ergonomics Applications |  |  |  |
| Ease of Handling |  |  |  |
| Correct tool |  |  |  |
| Eliminate special tools |  |  |  |
| Avoid "washrag" postures |  |  |  |
| Comfort zone |  |  |  |
|  |  |  |  |

## Ergonomics in DFMA Problem Solving Form

Use this form to identify opportunities for improvement in the product design process

1) Check the design principle is violated
2) Note the specific part that could be improved
3) Briefly note the anticipated improvement
4) Use the form on the reverse side / following page to more develop the recommendations.

| oduct name | Vertical transfer line | Name: | Rack / Vacuum chamber | Date | 5.8.2012 |
| :---: | :---: | :---: | :---: | :---: | :---: |


| DFMA Principle | Violation | Part | Anticipated improvement |
| :--- | :--- | :--- | :--- |
| Design for stable base |  |  |  |
| Minimize reorientation |  |  |  |
| Insertion point easy to see and reach |  |  |  |
| Decrease need for specialized fixtures |  |  |  |
| Insertion of parts |  |  |  |
| Decrease ambiguity in part/subassembly orientation |  |  |  |
| Design parts with self locking features |  |  |  |
| Fail-safe Assembly |  |  |  |
| Minimize part count/levels of assembly |  |  |  |
| Minimize levels of assembly |  |  |  |
| Minimize number/types of fasteners, cables, etc. |  |  |  |
| Modular, interchangeable assemblies |  |  |  |
| Self-fastening features |  |  |  |
| Use unique characteristics of the material |  |  |  |
| Built-in springs |  |  |  |
| Pressed or molded parts |  |  |  |
| Injection-molded buttons or signs |  |  |  |
| Ergonomics Applications |  |  |  |
| Ease of Handling |  |  |  |
| Correct tool |  |  |  |
| Eliminate special tools |  |  |  |
| Avoid "washrag" postures |  |  |  |
| Elinate mechanical pressure |  |  |  |
|  |  |  |  |

## Ergonomics in DFMA Problem Solving Form

Use this form to identify opportunities for improvement in the product design process

1) Check the design principle is violated
2) Note the specific part that could be improved
3) Briefly note the anticipated improvement
4) Use the form on the reverse side / following page to more develop the recommendations.

Product name: | Vertical transfer line | Name: |
| :--- | :--- |
| Rack / Quardrupole Triplet | Date: 15.8 .2012 |

| DFMA Principle | Violation | Part | Anticipated improvement |
| :--- | :--- | :--- | :--- |
| Design for stable base |  |  |  |
| Minimize reorientation |  |  |  |
| Insertion point easy to see and reach |  |  |  |
| Decrease need for specialized fixtures |  |  |  |
| Insertion of parts |  |  |  |
| Decrease ambiguity in part/subassembly orientation |  |  |  |
| Design parts with self locking features |  |  |  |
| Fail-safe Assembly |  |  |  |
| Minimize part count/levels of assembly |  |  |  |
| Minimize levels of assembly |  |  |  |
| Minimize number/types of fasteners, cables, etc. |  |  |  |
| Modular, interchangeable assemblies |  |  |  |
| Self-fastening features |  |  |  |
| Use unique characteristics of the material |  |  |  |
| Built-in springs |  |  |  |
| Pressed or molded parts |  |  |  |
| Injection-molded buttons or signs |  |  |  |
| Ergonomics Applications |  |  |  |
| Ease of Handling |  |  |  |
| Correct tool |  |  |  |
| Eliminate special tools |  |  |  |
| Avoid "washrag" postures |  |  |  |
| Comfort zone |  |  |  |
|  |  |  |  |

## C. List of commercial parts

On this list are described all the major components but attaching elements like screws and anchor bolts are not included.

List of commercial small parts for the support system of the vertical transfer line


| 4. Cover Cap $90 \times 90$ Connection Angle 45 | WMH 321180 | 16 pcs. |  |
| :---: | :---: | :---: | :---: |
| 5. Central Connector $0^{\circ}$ | 099B10171000 | 20 pcs. <br> 16 pcs. | $\begin{aligned} & \mathrm{d}=17 \mathrm{~mm} \\ & \mathrm{~b}=22.5 \mathrm{~mm} \end{aligned}$ |
| 6. Central Connector $90^{\circ}$ | 099B10171090 | 16 pcs. <br> 16 pcs. |  |
| 7. Profile nut PMK-2 |  | - |  |
| 8. Cover Cap 45x90 | WMH 401060 | 12 pcs . |  |



| 13. Transport and Base | 093T45901008R | 8 pcs |  |
| :--- | :--- | :--- | :--- |
| Plate $45 \times 90$ |  |  |  |
|  |  | 8 pcs |  |
| 14. Self Tapping Bush M8 | 340 ME 111 |  |  |

## D. Assembly drawings

List of assembly drawings:

1. KR3-A007.01 Vacuum Chamber
2. KR3-A025 6-Cross Chamber Rack
3. KR3-A027 Vacuum Chamber Support Frame
4. KR3-A033 Wall Support Assembly
5. KR3-A034 Vacuum Pump Rack Assembly
6. KR3-A040 Equipment Rack, Quadrupole Triplet
7. KR3-A041 Equipment Rack, Diagnostic Box
8. KR3-A048 Lining tool, assembly
9. KR3-A052 Quide D17 mm, assembly
10. KR3-A061 Ground electrode D30 asssembly
11. KR3-A062 Extractor D30 assembly
12. KR3-A067 Einzel lens assembly
13. KR3-A071 Extractor chamber assembly
14. KR3-A075 6-cross chamber equipment assembly
15. KR3-A078 Dielectric breakdown distance
16. KR3-A080 Support, VAT-valve
17. KR3-A083 Test ion source assembly















## E. Manufacturing drawings

List of manufacturing drawings:

1. KR3-A051 Drilling guide
2. KR3-A059 HV-insulator, $\mathrm{L}=100$
3. KR3-A069 Pipe DN100 L=380
4. KR3-A070 Extractor chamber $\mathrm{L}=80$
5. KR3-A077 Lining tool, ion optics



## F. Ion optical simulation

Datasheets 1-8 includes the coordinates of the distripution of 500 particles of the ion beam simulation, perpendicular to the ion beam of flight.

Data sheet 1: Particles 1-64
Data sheet 2: Particles 65-128
Data sheet 3: Particles 196-192
Data sheet 4: Particles 193-256
Data sheet 5: Particles 257-320
Data sheet 6: Particles 321-384
Data sheet 7: Particles 385-448
Data sheet 8: Particles 449-500

| Particle | X | Hit $\mathrm{Y}=$ | Z | X-50 | Z-25 |
| :---: | :---: | :---: | :---: | :---: | :---: |
| 1 | 52,1502 | -384 | 22,1211 | 2,1502 | -2,8789 |
| 2 | 48,1186 | -384 | 23,9962 | -1,8814 | -1,0038 |
| 3 | 49,192 | -384 | 24,0051 | -0,808 | -0,9949 |
| 4 | 48,9286 | -384 | 24,0501 | -1,0714 | -0,9499 |
| 5 | 50,616 | -384 | 24,3949 | 0,616 | -0,6051 |
| 6 | 51,3583 | -384 | 24,9461 | 1,3583 | -0,0539 |
| 7 | 49,7583 | -384 | 24,6916 | -0,2417 | -0,3084 |
| 8 | 49,4418 | -384 | 20,8943 | -0,5582 | -4,1057 |
| 9 | 49,0201 | -384 | 21,9975 | -0,9799 | -3,0025 |
| 10 | 48,8214 | -384 | 20,982 | -1,1786 | -4,018 |
| 11 | 51,6448 | -384 | 21,7704 | 1,6448 | -3,2296 |
| 12 | 50,1441 | -384 | 23,3313 | 0,1441 | -1,6687 |
| 13 | 49,963 | -384 | 21,0146 | -0,037 | -3,9854 |
| 14 | 49,0752 | -384 | 23,5855 | -0,9248 | -1,4145 |
| 15 | 48,5399 | -384 | 23,469 | -1,4601 | -1,531 |
| 16 | 49,3188 | -384 | 23,204 | -0,6812 | -1,796 |
| 17 | 47,9396 | -384 | 22,1227 | -2,0604 | -2,8773 |
| 18 | 50,5727 | -384 | 25,3074 | 0,5727 | 0,3074 |
| 19 | 47,978 | -384 | 22,9728 | -2,022 | -2,0272 |
| 20 | 52,3106 | -384 | 21,6488 | 2,3106 | -3,3512 |
| 21 | 48,9691 | -384 | 20,8892 | -1,0309 | -4,1108 |
| 22 | 50,2252 | -384 | 24,6467 | 0,2252 | -0,3533 |
| 23 | 49,1522 | -384 | 23,2859 | -0,8478 | -1,7141 |
| 24 | 52,0454 | -384 | 24,391 | 2,0454 | -0,609 |
| 25 | 49,2545 | -384 | 23,5761 | -0,7455 | -1,4239 |
| 26 | 48,215 | -384 | 23,6288 | -1,785 | -1,3712 |
| 27 | 48,1744 | -384 | 24,0879 | -1,8256 | -0,9121 |
| 28 | 51,9493 | -384 | 24,189 | 1,9493 | -0,811 |
| 29 | 48,2829 | -384 | 24,0953 | -1,7171 | -0,9047 |
| 30 | 52,4348 | -384 | 23,7039 | 2,4348 | -1,2961 |
| 31 | 49,7815 | -384 | 21,931 | -0,2185 | -3,069 |
| 32 | 50,7004 | -384 | 22,2879 | 0,7004 | -2,7121 |
| 33 | 49,4465 | -384 | 24,706 | -0,5535 | -0,294 |
| 34 | 52,68 | -384 | 22,8124 | 2,68 | -2,1876 |
| 35 | 48,0569 | -384 | 22,8058 | -1,9431 | -2,1942 |
| 36 | 48,1045 | -384 | 24,2627 | -1,8955 | -0,7373 |
| 37 | 49,218 | -384 | 23,3481 | -0,782 | -1,6519 |
| 38 | 50,3676 | -384 | 25,1436 | 0,3676 | 0,1436 |
| 39 | 51,4408 | -384 | 24,0513 | 1,4408 | -0,9487 |
| 40 | 49,554 | -384 | 23,5055 | -0,446 | -1,4945 |
| 41 | 49,0637 | -384 | 22,5299 | -0,9363 | -2,4701 |
| 42 | 48,1823 | -384 | 23,6642 | -1,8177 | -1,3358 |
| 43 | 50,7304 | -384 | 23,0476 | 0,7304 | -1,9524 |
| 44 | 48,9636 | -384 | 25,0931 | -1,0364 | 0,0931 |
| 45 | 48,1758 | -384 | 22,9132 | -1,8242 | -2,0868 |
| 46 | 48,8891 | -384 | 21,3066 | -1,1109 | -3,6934 |
| 47 | 50,9892 | -384 | 21,3905 | 0,9892 | -3,6095 |
| 48 | 52,9947 | -384 | 24,2137 | 2,9947 | -0,7863 |
| 49 | 49,125 | -384 | 21,5319 | -0,875 | -3,4681 |
| 50 | 50,5971 | -384 | 25,5879 | 0,5971 | 0,5879 |
| 51 | 48,1482 | -384 | 23,4154 | -1,8518 | -1,5846 |
| 52 | 49,5801 | -384 | 23,3863 | -0,4199 | -1,6137 |
| 53 | 49,5153 | -384 | 25,4283 | -0,4847 | 0,4283 |
| 54 | 47,9192 | -384 | 23,1251 | -2,0808 | -1,8749 |
| 55 | 51,0134 | -384 | 22,3678 | 1,0134 | -2,6322 |
| 56 | 50,7439 | -384 | 23,7182 | 0,7439 | -1,2818 |
| 57 | 48,0817 | -384 | 24,1796 | -1,9183 | -0,8204 |
| 58 | 49,4783 | -384 | 25,0643 | -0,5217 | 0,0643 |
| 59 | 52,7203 | -384 | 23,1638 | 2,7203 | -1,8362 |
| 60 | 49,3034 | -384 | 21,3597 | -0,6966 | -3,6403 |
| 61 | 51,3922 | -384 | 22,3556 | 1,3922 | -2,6444 |
| 62 | 49,8533 | -384 | 23,6856 | -0,1467 | -1,3144 |
| 63 | 48,0641 | -384 | 24,2549 | -1,9359 | -0,7451 |
| 64 | 49,5683 | -384 | 23,2163 | -0,4317 | -1,7837 |


| Particle | X | Hit $Y=$ | Z | X-50 | Z-25 |
| :---: | :---: | :---: | :---: | :---: | :---: |
| 65 | 50,6017 | -384 | 22,1885 | 0,6017 | -2,8115 |
| 66 | 49,3984 | -384 | 24,0472 | -0,6016 | -0,9528 |
| 67 | 48,5215 | -384 | 22,644 | -1,4785 | -2,356 |
| 68 | 51,0178 | -384 | 21,7137 | 1,0178 | -3,2863 |
| 69 | 48,1223 | -384 | 21,8798 | -1,8777 | -3,1202 |
| 70 | 48,9228 | -384 | 21,5903 | -1,0772 | -3,4097 |
| 71 | 48,2674 | -384 | 23,3055 | -1,7326 | -1,6945 |
| 72 | 51,6964 | -384 | 24,902 | 1,6964 | -0,098 |
| 73 | 51,4327 | -384 | 25,1214 | 1,4327 | 0,1214 |
| 74 | 53,0577 | -384 | 24,2683 | 3,0577 | -0,7317 |
| 75 | 48,8011 | -384 | 21,191 | -1,1989 | -3,809 |
| 76 | 49,1549 | -384 | 24,1932 | -0,8451 | -0,8068 |
| 77 | 52,4277 | -384 | 22,4258 | 2,4277 | -2,5742 |
| 78 | 49,2193 | -384 | 24,166 | -0,7807 | -0,834 |
| 79 | 51,4727 | -384 | 24,7273 | 1,4727 | -0,2727 |
| 80 | 48,0242 | -384 | 23,6339 | -1,9758 | -1,3661 |
| 81 | 48,226 | -384 | 24,2228 | -1,774 | -0,7772 |
| 82 | 51,4229 | -384 | 22,7843 | 1,4229 | -2,2157 |
| 83 | 48,0483 | -384 | 23,7671 | -1,9517 | -1,2329 |
| 84 | 52,9008 | -384 | 24,2863 | 2,9008 | -0,7137 |
| 85 | 50,4283 | -384 | 21,5386 | 0,4283 | -3,4614 |
| 86 | 50,6879 | -384 | 22,049 | 0,6879 | -2,951 |
| 87 | 48,2319 | -384 | 25,1059 | -1,7681 | 0,1059 |
| 88 | 47,9951 | -384 | 21,8957 | -2,0049 | -3,1043 |
| 89 | 48,7511 | -384 | 22,8263 | -1,2489 | -2,1737 |
| 90 | 49,2223 | -384 | 23,5259 | -0,7777 | -1,4741 |
| 91 | 52,3567 | -384 | 21,9503 | 2,3567 | -3,0497 |
| 92 | 48,4857 | -384 | 23,4566 | -1,5143 | -1,5434 |
| 93 | 50,2441 | -384 | 23,4801 | 0,2441 | -1,5199 |
| 94 | 48,1736 | -384 | 24,0365 | -1,8264 | -0,9635 |
| 95 | 51,6799 | -384 | 22,4483 | 1,6799 | -2,5517 |
| 96 | 49,5605 | -384 | 22,9395 | -0,4395 | -2,0605 |
| 97 | 48,9931 | -384 | 25,4637 | -1,0069 | 0,4637 |
| 98 | 50,2816 | -384 | 24,3626 | 0,2816 | -0,6374 |
| 99 | 49,2287 | -384 | 24,2547 | -0,7713 | -0,7453 |
| 100 | 50,107 | -384 | 23,3091 | 0,107 | -1,6909 |
| 101 | 50,8174 | -384 | 24,6692 | 0,8174 | -0,3308 |
| 102 | 52,138 | -384 | 23,3635 | 2,138 | -1,6365 |
| 103 | 47,905 | -384 | 22,3258 | -2,095 | -2,6742 |
| 104 | 50,8846 | -384 | 22,1433 | 0,8846 | -2,8567 |
| 105 | 50,462 | -384 | 21,4079 | 0,462 | -3,5921 |
| 106 | 49,5598 | -384 | 22,0718 | -0,4402 | -2,9282 |
| 107 | 48,0942 | -384 | 21,359 | -1,9058 | -3,641 |
| 108 | 49,1946 | -384 | 24,565 | -0,8054 | -0,435 |
| 109 | 49,3803 | -384 | 23,7227 | -0,6197 | -1,2773 |
| 110 | 49,2381 | -384 | 25,3702 | -0,7619 | 0,3702 |
| 111 | 48,895 | -384 | 25,4908 | -1,105 | 0,4908 |
| 112 | 49,3066 | -384 | 22,9549 | -0,6934 | -2,0451 |
| 113 | 50,3462 | -384 | 25,3969 | 0,3462 | 0,3969 |
| 114 | 48,1608 | -384 | 22,8073 | -1,8392 | -2,1927 |
| 115 | 50,2343 | -384 | 23,1994 | 0,2343 | -1,8006 |
| 116 | 49,0195 | -384 | 21,5475 | -0,9805 | -3,4525 |
| 117 | 48,129 | -384 | 22,3314 | -1,871 | -2,6686 |
| 118 | 48,653 | -384 | 25,2525 | -1,347 | 0,2525 |
| 119 | 51,3009 | -384 | 24,4506 | 1,3009 | -0,5494 |
| 120 | 49,3983 | -384 | 24,4936 | -0,6017 | -0,5064 |
| 121 | 49,5469 | -384 | 25,5182 | -0,4531 | 0,5182 |
| 122 | 48,2175 | -384 | 23,1509 | -1,7825 | -1,8491 |
| 123 | 51,8919 | -384 | 23,5949 | 1,8919 | -1,4051 |
| 124 | 50,9565 | -384 | 24,351 | 0,9565 | -0,649 |
| 125 | 52,711 | -384 | 22,4001 | 2,711 | -2,5999 |
| 126 | 48,1645 | -384 | 23,6635 | -1,8355 | -1,3365 |
| 127 | 50,044 | -384 | 20,8973 | 0,044 | -4,1027 |
| 128 | 48,3459 | -384 | 24,9834 | -1,6541 | -0,0166 |


| Particle | X | Hit $\mathrm{Y}=$ | Z | X - 50 | Z-25 |
| :---: | :---: | :---: | :---: | :---: | :---: |
| 129 | 48,3041 | -384 | 24,4681 | -1,6959 | -0,5319 |
| 130 | 49,5998 | -384 | 22,4289 | -0,4002 | -2,5711 |
| 131 | 51,0323 | -384 | 25,4331 | 1,0323 | 0,4331 |
| 132 | 51,2959 | -384 | 24,228 | 1,2959 | -0,772 |
| 133 | 48,0221 | -384 | 22,054 | -1,9779 | -2,946 |
| 134 | 48,4945 | -384 | 23,5259 | -1,5055 | -1,4741 |
| 135 | 51,5808 | -384 | 24,3897 | 1,5808 | -0,6103 |
| 136 | 50,1056 | -384 | 21,9141 | 0,1056 | -3,0859 |
| 137 | 50,1333 | -384 | 21,6089 | 0,1333 | -3,3911 |
| 138 | 49,2219 | -384 | 24,1393 | -0,7781 | -0,8607 |
| 139 | 49,5649 | -384 | 24,8859 | -0,4351 | -0,1141 |
| 140 | 52,5248 | -384 | 21,7682 | 2,5248 | -3,2318 |
| 141 | 50,6214 | -384 | 22,9644 | 0,6214 | -2,0356 |
| 142 | 49,1983 | -384 | 23,4786 | -0,8017 | -1,5214 |
| 143 | 49,153 | -384 | 23,5308 | -0,847 | -1,4692 |
| 144 | 49,4019 | -384 | 23,6523 | -0,5981 | -1,3477 |
| 145 | 49,7811 | -384 | 22,7602 | -0,2189 | -2,2398 |
| 146 | 49,0997 | -384 | 23,7693 | -0,9003 | -1,2307 |
| 147 | 48,9492 | -384 | 23,7336 | -1,0508 | -1,2664 |
| 148 | 50,1211 | -384 | 21,3222 | 0,1211 | -3,6778 |
| 149 | 49,2861 | -384 | 24,7795 | -0,7139 | -0,2205 |
| 150 | 49,0734 | -384 | 24,6423 | -0,9266 | -0,3577 |
| 151 | 48,5758 | -384 | 23,8774 | -1,4242 | -1,1226 |
| 152 | 48,7429 | -384 | 20,7727 | -1,2571 | -4,2273 |
| 153 | 49,1732 | -384 | 23,6717 | -0,8268 | -1,3283 |
| 154 | 49,0819 | -384 | 24,4578 | -0,9181 | -0,5422 |
| 155 | 48,4994 | -384 | 23,2792 | -1,5006 | -1,7208 |
| 156 | 49,2715 | -384 | 22,2294 | -0,7285 | -2,7706 |
| 157 | 53,1206 | -384 | 23,8985 | 3,1206 | -1,1015 |
| 158 | 52,7615 | -384 | 22,9507 | 2,7615 | -2,0493 |
| 159 | 49,0124 | -384 | 21,9288 | -0,9876 | -3,0712 |
| 160 | 48,1398 | -384 | 22,0939 | -1,8602 | -2,9061 |
| 161 | 48,8989 | -384 | 25,3312 | -1,1011 | 0,3312 |
| 162 | 51,9563 | -384 | 24,2447 | 1,9563 | -0,7553 |
| 163 | 48,7294 | -384 | 20,8278 | -1,2706 | -4,1722 |
| 164 | 48,487 | -384 | 21,6759 | -1,513 | -3,3241 |
| 165 | 48,044 | -384 | 21,0889 | -1,956 | -3,9111 |
| 166 | 51,733 | -384 | 21,4986 | 1,733 | -3,5014 |
| 167 | 49,2583 | -384 | 22,0439 | -0,7417 | -2,9561 |
| 168 | 47,9308 | -384 | 22,693 | -2,0692 | -2,307 |
| 169 | 49,4493 | -384 | 20,875 | -0,5507 | -4,125 |
| 170 | 50,5682 | -384 | 22,7509 | 0,5682 | -2,2491 |
| 171 | 49,2305 | -384 | 22,9443 | -0,7695 | -2,0557 |
| 172 | 51,5407 | -384 | 24,9752 | 1,5407 | -0,0248 |
| 173 | 53,3633 | -384 | 23,1775 | 3,3633 | -1,8225 |
| 174 | 51,5056 | -384 | 24,7171 | 1,5056 | -0,2829 |
| 175 | 47,9781 | -384 | 22,5777 | -2,0219 | -2,4223 |
| 176 | 49,7879 | -384 | 21,0434 | -0,2121 | -3,9566 |
| 177 | 48,3632 | -384 | 21,2857 | -1,6368 | -3,7143 |
| 178 | 48,0439 | -384 | 22,5915 | -1,9561 | -2,4085 |
| 179 | 49,5699 | -384 | 23,0506 | -0,4301 | -1,9494 |
| 180 | 50,5074 | -384 | 22,4959 | 0,5074 | -2,5041 |
| 181 | 48,1633 | -384 | 24,1874 | -1,8367 | -0,8126 |
| 182 | 48,2273 | -384 | 23,8936 | -1,7727 | -1,1064 |
| 183 | 51,3858 | -384 | 22,0176 | 1,3858 | -2,9824 |
| 184 | 50,7036 | -384 | 22,4834 | 0,7036 | -2,5166 |
| 185 | 48,0223 | -384 | 22,4786 | -1,9777 | -2,5214 |
| 186 | 48,9856 | -384 | 21,2899 | -1,0144 | -3,7101 |
| 187 | 51,5314 | -384 | 24,3874 | 1,5314 | -0,6126 |
| 188 | 48,0515 | -384 | 21,0073 | -1,9485 | -3,9927 |
| 189 | 51,8872 | -384 | 21,5287 | 1,8872 | -3,4713 |
| 190 | 49,4331 | -384 | 24,5486 | -0,5669 | -0,4514 |
| 191 | 49,3237 | -384 | 23,3599 | -0,6763 | -1,6401 |
| 192 | 50,3028 | -384 | 23,7934 | 0,3028 | -1,2066 |


| Particle | X | Hit $\mathrm{Y}=$ | Z | X - 50 | Z-25 |
| :---: | :---: | :---: | :---: | :---: | :---: |
| 193 | 49,1325 | -384 | 23,6384 | -0,8675 | -1,3616 |
| 194 | 48,1077 | -384 | 22,5059 | -1,8923 | -2,4941 |
| 195 | 50,7162 | -384 | 22,3622 | 0,7162 | -2,6378 |
| 196 | 49,3096 | -384 | 25,5826 | -0,6904 | 0,5826 |
| 197 | 49,3405 | -384 | 23,5773 | -0,6595 | -1,4227 |
| 198 | 51,1349 | -384 | 21,7174 | 1,1349 | -3,2826 |
| 199 | 49,0527 | -384 | 23,6872 | -0,9473 | -1,3128 |
| 200 | 48,1248 | -384 | 22,1899 | -1,8752 | -2,8101 |
| 201 | 51,9429 | -384 | 23,6166 | 1,9429 | -1,3834 |
| 202 | 52,8937 | -384 | 22,6361 | 2,8937 | -2,3639 |
| 203 | 48,5691 | -384 | 23,173 | -1,4309 | -1,827 |
| 204 | 48,2415 | -384 | 24,0878 | -1,7585 | -0,9122 |
| 205 | 48,2108 | -384 | 23,2832 | -1,7892 | -1,7168 |
| 206 | 48,0577 | -384 | 22,3731 | -1,9423 | -2,6269 |
| 207 | 50,2379 | -384 | 23,1092 | 0,2379 | -1,8908 |
| 208 | 49,6706 | -384 | 25,1984 | -0,3294 | 0,1984 |
| 209 | 50,6519 | -384 | 22,2152 | 0,6519 | -2,7848 |
| 210 | 48,3825 | -384 | 20,8912 | -1,6175 | -4,1088 |
| 211 | 48,9519 | -384 | 22,5375 | -1,0481 | -2,4625 |
| 212 | 48,3882 | -384 | 25,0192 | -1,6118 | 0,0192 |
| 213 | 48,96 | -384 | 21,8004 | -1,04 | -3,1996 |
| 214 | 48,0542 | -384 | 23,1716 | -1,9458 | -1,8284 |
| 215 | 48,9258 | -384 | 23,8927 | -1,0742 | -1,1073 |
| 216 | 49,3932 | -384 | 21,4493 | -0,6068 | -3,5507 |
| 217 | 52,1835 | -384 | 24,0664 | 2,1835 | -0,9336 |
| 218 | 50,4587 | -384 | 23,5882 | 0,4587 | -1,4118 |
| 219 | 51,4659 | -384 | 23,9613 | 1,4659 | -1,0387 |
| 220 | 50,6108 | -384 | 21,1711 | 0,6108 | -3,8289 |
| 221 | 48,278 | -384 | 23,8951 | -1,722 | -1,1049 |
| 222 | 49,5671 | -384 | 24,7741 | -0,4329 | -0,2259 |
| 223 | 51,2926 | -384 | 24,2844 | 1,2926 | -0,7156 |
| 224 | 48,1099 | -384 | 21,6189 | -1,8901 | -3,3811 |
| 225 | 49,4208 | -384 | 21,2488 | -0,5792 | -3,7512 |
| 226 | 50,767 | -384 | 24,0385 | 0,767 | -0,9615 |
| 227 | 48,9473 | -384 | 22,1764 | -1,0527 | -2,8236 |
| 228 | 51,1576 | -384 | 23,7632 | 1,1576 | -1,2368 |
| 229 | 48,0416 | -384 | 24,1767 | -1,9584 | -0,8233 |
| 230 | 49,0526 | -384 | 22,1828 | -0,9474 | -2,8172 |
| 231 | 49,0076 | -384 | 23,1219 | -0,9924 | -1,8781 |
| 232 | 50,5733 | -384 | 23,8718 | 0,5733 | -1,1282 |
| 233 | 49,487 | -384 | 24,9826 | -0,513 | -0,0174 |
| 234 | 51,9581 | -384 | 23,8628 | 1,9581 | -1,1372 |
| 235 | 49,7098 | -384 | 21,7021 | -0,2902 | -3,2979 |
| 236 | 47,9778 | -384 | 21,1544 | -2,0222 | -3,8456 |
| 237 | 52,1902 | -384 | 22,3946 | 2,1902 | -2,6054 |
| 238 | 48,0544 | -384 | 23,018 | -1,9456 | -1,982 |
| 239 | 49,6585 | -384 | 22,2994 | -0,3415 | -2,7006 |
| 240 | 47,9883 | -384 | 22,6312 | -2,0117 | -2,3688 |
| 241 | 49,3659 | -384 | 22,5341 | -0,6341 | -2,4659 |
| 242 | 51,8246 | -384 | 22,8185 | 1,8246 | -2,1815 |
| 243 | 47,9968 | -384 | 21,7382 | -2,0032 | -3,2618 |
| 244 | 48,1443 | -384 | 23,9646 | -1,8557 | -1,0354 |
| 245 | 51,8837 | -384 | 23,4265 | 1,8837 | -1,5735 |
| 246 | 50,0666 | -384 | 20,758 | 0,0666 | -4,242 |
| 247 | 49,7792 | -384 | 25,6508 | -0,2208 | 0,6508 |
| 248 | 48,2276 | -384 | 24,1982 | -1,7724 | -0,8018 |
| 249 | 48,5107 | -384 | 22,6606 | -1,4893 | -2,3394 |
| 250 | 48,9395 | -384 | 21,4166 | -1,0605 | -3,5834 |
| 251 | 48,168 | -384 | 23,6619 | -1,832 | -1,3381 |
| 252 | 48,278 | -384 | 23,7704 | -1,722 | -1,2296 |
| 253 | 49,8648 | -384 | 25,0719 | -0,1352 | 0,0719 |
| 254 | 49,2388 | -384 | 21,2919 | -0,7612 | -3,7081 |
| 255 | 47,9676 | -384 | 23,448 | -2,0324 | -1,552 |
| 256 | 52,7304 | -384 | 22,5305 | 2,7304 | -2,4695 |


| Particle | X | Hit $\mathrm{Y}=$ | Z | X-50 | Z-25 |
| :---: | :---: | :---: | :---: | :---: | :---: |
| 257 | 49,2815 | -384 | 22,4041 | -0,7185 | -2,5959 |
| 258 | 53,0594 | -384 | 24,0408 | 3,0594 | -0,9592 |
| 259 | 48,6525 | -384 | 25,0594 | -1,3475 | 0,0594 |
| 260 | 50,5946 | -384 | 21,0614 | 0,5946 | -3,9386 |
| 261 | 52,0479 | -384 | 21,7478 | 2,0479 | -3,2522 |
| 262 | 50,0633 | -384 | 24,6882 | 0,0633 | -0,3118 |
| 263 | 48,0558 | -384 | 22,8075 | -1,9442 | -2,1925 |
| 264 | 50,4236 | -384 | 25,6522 | 0,4236 | 0,6522 |
| 265 | 49,3308 | -384 | 24,9822 | -0,6692 | -0,0178 |
| 266 | 49,1282 | -384 | 24,6209 | -0,8718 | -0,3791 |
| 267 | 50,1515 | -384 | 22,8307 | 0,1515 | -2,1693 |
| 268 | 48,3137 | -384 | 24,6795 | -1,6863 | -0,3205 |
| 269 | 48,65 | -384 | 24,1561 | -1,35 | -0,8439 |
| 270 | 52,3035 | -384 | 22,1177 | 2,3035 | -2,8823 |
| 271 | 49,8631 | -384 | 21,8933 | -0,1369 | -3,1067 |
| 272 | 51,3871 | -384 | 22,6441 | 1,3871 | -2,3559 |
| 273 | 50,8962 | -384 | 22,3893 | 0,8962 | -2,6107 |
| 274 | 48,0008 | -384 | 21,3556 | -1,9992 | -3,6444 |
| 275 | 47,9021 | -384 | 22,2745 | -2,0979 | -2,7255 |
| 276 | 48,9215 | -384 | 20,8708 | -1,0785 | -4,1292 |
| 277 | 49,1779 | -384 | 20,59 | -0,8221 | -4,41 |
| 278 | 49,1969 | -384 | 24,3628 | -0,8031 | -0,6372 |
| 279 | 50,5037 | -384 | 24,3054 | 0,5037 | -0,6946 |
| 280 | 51,1142 | -384 | 22,9902 | 1,1142 | -2,0098 |
| 281 | 48,8669 | -384 | 22,3907 | -1,1331 | -2,6093 |
| 282 | 48,8819 | -384 | 21,3816 | -1,1181 | -3,6184 |
| 283 | 50,8076 | -384 | 23,2132 | 0,8076 | -1,7868 |
| 284 | 48,529 | -384 | 21,1638 | -1,471 | -3,8362 |
| 285 | 48,9276 | -384 | 24,7085 | -1,0724 | -0,2915 |
| 286 | 48,443 | -384 | 23,6297 | -1,557 | -1,3703 |
| 287 | 50,1987 | -384 | 22,619 | 0,1987 | -2,381 |
| 288 | 48,1472 | -384 | 23,4225 | -1,8528 | -1,5775 |
| 289 | 50,3983 | -384 | 22,1178 | 0,3983 | -2,8822 |
| 290 | 49,131 | -384 | 21,5951 | -0,869 | -3,4049 |
| 291 | 48,8028 | -384 | 24,1328 | -1,1972 | -0,8672 |
| 292 | 48,6845 | -384 | 23,2743 | -1,3155 | -1,7257 |
| 293 | 50,751 | -384 | 21,3874 | 0,751 | -3,6126 |
| 294 | 49,9745 | -384 | 24,6197 | -0,0255 | -0,3803 |
| 295 | 48,9734 | -384 | 24,2795 | -1,0266 | -0,7205 |
| 296 | 51,8606 | -384 | 21,7301 | 1,8606 | -3,2699 |
| 297 | 52,8771 | -384 | 22,5372 | 2,8771 | -2,4628 |
| 298 | 49,8017 | -384 | 23,0799 | -0,1983 | -1,9201 |
| 299 | 48,7677 | -384 | 21,3624 | -1,2323 | -3,6376 |
| 300 | 49,4654 | -384 | 22,6734 | -0,5346 | -2,3266 |
| 301 | 51,3685 | -384 | 24,2491 | 1,3685 | -0,7509 |
| 302 | 49,0669 | -384 | 22,1921 | -0,9331 | -2,8079 |
| 303 | 48,0057 | -384 | 22,444 | -1,9943 | -2,556 |
| 304 | 50,8957 | -384 | 23,2267 | 0,8957 | -1,7733 |
| 305 | 51,9426 | -384 | 22,6733 | 1,9426 | -2,3267 |
| 306 | 52,5338 | -384 | 23,0961 | 2,5338 | -1,9039 |
| 307 | 49,2405 | -384 | 20,8004 | -0,7595 | -4,1996 |
| 308 | 50,2834 | -384 | 23,7631 | 0,2834 | -1,2369 |
| 309 | 48,1901 | -384 | 24,2108 | -1,8099 | -0,7892 |
| 310 | 49,4235 | -384 | 25,404 | -0,5765 | 0,404 |
| 311 | 49,0347 | -384 | 21,5177 | -0,9653 | -3,4823 |
| 312 | 49,2689 | -384 | 25,1362 | -0,7311 | 0,1362 |
| 313 | 48,572 | -384 | 22,1009 | -1,428 | -2,8991 |
| 314 | 48,1274 | -384 | 21,8327 | -1,8726 | -3,1673 |
| 315 | 50,8183 | -384 | 23,6317 | 0,8183 | -1,3683 |
| 316 | 49,351 | -384 | 23,566 | -0,649 | -1,434 |
| 317 | 49,4943 | -384 | 21,7399 | -0,5057 | -3,2601 |
| 318 | 48,2633 | -384 | 24,6972 | -1,7367 | -0,3028 |
| 319 | 49,6032 | -384 | 24,0082 | -0,3968 | -0,9918 |
| 320 | 48,5071 | -384 | 24,1077 | -1,4929 | -0,8923 |


| Particle | X | Hit $\mathrm{Y}=$ | Z | X-50 | Z-25 |
| :---: | :---: | :---: | :---: | :---: | :---: |
| 321 | 49,0439 | -384 | 23,0696 | -0,9561 | -1,9304 |
| 322 | 50,4675 | -384 | 23,9764 | 0,4675 | -1,0236 |
| 323 | 50,6347 | -384 | 21,0095 | 0,6347 | -3,9905 |
| 324 | 47,996 | -384 | 22,6243 | -2,004 | -2,3757 |
| 325 | 48,9981 | -384 | 20,5826 | -1,0019 | -4,4174 |
| 326 | 53,3034 | -384 | 23,2962 | 3,3034 | -1,7038 |
| 327 | 49,2105 | -384 | 21,8807 | -0,7895 | -3,1193 |
| 328 | 48,5215 | -384 | 21,6106 | -1,4785 | -3,3894 |
| 329 | 50,7779 | -384 | 23,0857 | 0,7779 | -1,9143 |
| 330 | 48,0932 | -384 | 23,3164 | -1,9068 | -1,6836 |
| 331 | 48,3366 | -384 | 20,8955 | -1,6634 | -4,1045 |
| 332 | 50,3156 | -384 | 21,2816 | 0,3156 | -3,7184 |
| 333 | 50,1137 | -384 | 24,3764 | 0,1137 | -0,6236 |
| 334 | 50,6447 | -384 | 22,0665 | 0,6447 | -2,9335 |
| 335 | 48,39 | -384 | 25,0346 | -1,61 | 0,0346 |
| 336 | 51,6599 | -384 | 21,7223 | 1,6599 | -3,2777 |
| 337 | 51,1895 | -384 | 21,883 | 1,1895 | -3,117 |
| 338 | 50,4386 | -384 | 25,3948 | 0,4386 | 0,3948 |
| 339 | 49,0144 | -384 | 22,5493 | -0,9856 | -2,4507 |
| 340 | 50,1511 | -384 | 22,6579 | 0,1511 | -2,3421 |
| 341 | 48,7281 | -384 | 22,8493 | -1,2719 | -2,1507 |
| 342 | 48,1232 | -384 | 23,3917 | -1,8768 | -1,6083 |
| 343 | 48,7598 | -384 | 22,2462 | -1,2402 | -2,7538 |
| 344 | 47,9281 | -384 | 21,5377 | -2,0719 | -3,4623 |
| 345 | 47,9171 | -384 | 21,8211 | -2,0829 | -3,1789 |
| 346 | 51,4329 | -384 | 23,7647 | 1,4329 | -1,2353 |
| 347 | 49,3291 | -384 | 25,4514 | -0,6709 | 0,4514 |
| 348 | 51,0624 | -384 | 24,796 | 1,0624 | -0,204 |
| 349 | 52,8664 | -384 | 22,2403 | 2,8664 | -2,7597 |
| 350 | 52,4114 | -384 | 23,9339 | 2,4114 | -1,0661 |
| 351 | 51,0593 | -384 | 21,377 | 1,0593 | -3,623 |
| 352 | 52,7259 | -384 | 22,5181 | 2,7259 | -2,4819 |
| 353 | 51,3937 | -384 | 25,3511 | 1,3937 | 0,3511 |
| 354 | 52,71 | -384 | 23,0589 | 2,71 | -1,9411 |
| 355 | 49,5869 | -384 | 24,579 | -0,4131 | -0,421 |
| 356 | 49,3128 | -384 | 22,8782 | -0,6872 | -2,1218 |
| 357 | 49,1512 | -384 | 23,5043 | -0,8488 | -1,4957 |
| 358 | 48,3883 | -384 | 24,7541 | -1,6117 | -0,2459 |
| 359 | 47,98 | -384 | 21,2745 | -2,02 | -3,7255 |
| 360 | 53,0572 | -384 | 23,8414 | 3,0572 | -1,1586 |
| 361 | 51,7532 | -384 | 23,3402 | 1,7532 | -1,6598 |
| 362 | 50,7868 | -384 | 22,7191 | 0,7868 | -2,2809 |
| 363 | 47,9336 | -384 | 21,89 | -2,0664 | -3,11 |
| 364 | 49,02 | -384 | 22,5326 | -0,98 | -2,4674 |
| 365 | 48,1248 | -384 | 21,8559 | -1,8752 | -3,1441 |
| 366 | 51,4394 | -384 | 23,2448 | 1,4394 | -1,7552 |
| 367 | 48,7549 | -384 | 21,7157 | -1,2451 | -3,2843 |
| 368 | 50,1073 | -384 | 21,125 | 0,1073 | -3,875 |
| 369 | 50,4632 | -384 | 21,6954 | 0,4632 | -3,3046 |
| 370 | 51,4332 | -384 | 24,2108 | 1,4332 | -0,7892 |
| 371 | 48,6302 | -384 | 23,5734 | -1,3698 | -1,4266 |
| 372 | 50,3177 | -384 | 24,5237 | 0,3177 | -0,4763 |
| 373 | 49,5188 | -384 | 25,3378 | -0,4812 | 0,3378 |
| 374 | 49,2099 | -384 | 25,6544 | -0,7901 | 0,6544 |
| 375 | 49,0508 | -384 | 21,806 | -0,9492 | -3,194 |
| 376 | 49,4279 | -384 | 23,7927 | -0,5721 | -1,2073 |
| 377 | 49,5724 | -384 | 22,5721 | -0,4276 | -2,4279 |
| 378 | 50,8384 | -384 | 24,8574 | 0,8384 | -0,1426 |
| 379 | 48,9706 | -384 | 22,6486 | -1,0294 | -2,3514 |
| 380 | 51,8742 | -384 | 24,3266 | 1,8742 | -0,6734 |
| 381 | 50,5056 | -384 | 25,6053 | 0,5056 | 0,6053 |
| 382 | 49,7421 | -384 | 25,5186 | -0,2579 | 0,5186 |
| 383 | 49,9163 | -384 | 21,6041 | -0,0837 | -3,3959 |
| 384 | 52,154 | -384 | 21,6117 | 2,154 | -3,3883 |


| Particle | X | Hit $Y=$ | Z | X-50 | Z-25 |
| :---: | :---: | :---: | :---: | :---: | :---: |
| 385 | 48,3069 | -384 | 24,7082 | -1,6931 | -0,2918 |
| 386 | 48,7326 | -384 | 21,3774 | -1,2674 | -3,6226 |
| 387 | 48,0323 | -384 | 23,8429 | -1,9677 | -1,1571 |
| 388 | 49,1695 | -384 | 24,1707 | -0,8305 | -0,8293 |
| 389 | 48,1028 | -384 | 21,5792 | -1,8972 | -3,4208 |
| 390 | 48,8709 | -384 | 22,888 | -1,1291 | -2,112 |
| 391 | 48,2797 | -384 | 25,2847 | -1,7203 | 0,2847 |
| 392 | 52,849 | -384 | 24,542 | 2,849 | -0,458 |
| 393 | 48,0947 | -384 | 23,5287 | -1,9053 | -1,4713 |
| 394 | 50,1445 | -384 | 21,6774 | 0,1445 | -3,3226 |
| 395 | 48,0782 | -384 | 21,6684 | -1,9218 | -3,3316 |
| 396 | 48,3955 | -384 | 24,9748 | -1,6045 | -0,0252 |
| 397 | 53,0817 | -384 | 24,3121 | 3,0817 | -0,6879 |
| 398 | 49,0342 | -384 | 23,0038 | -0,9658 | -1,9962 |
| 399 | 53,127 | -384 | 22,8834 | 3,127 | -2,1166 |
| 400 | 47,9538 | -384 | 23,3177 | -2,0462 | -1,6823 |
| 401 | 52,512 | -384 | 23,3033 | 2,512 | -1,6967 |
| 402 | 51,2322 | -384 | 22,195 | 1,2322 | -2,805 |
| 403 | 52,055 | -384 | 22,0025 | 2,055 | -2,9975 |
| 404 | 50,763 | -384 | 22,4368 | 0,763 | -2,5632 |
| 405 | 49,0921 | -384 | 22,2706 | -0,9079 | -2,7294 |
| 406 | 49,0666 | -384 | 22,6202 | -0,9334 | -2,3798 |
| 407 | 48,0447 | -384 | 22,7255 | -1,9553 | -2,2745 |
| 408 | 49,0216 | -384 | 23,7382 | -0,9784 | -1,2618 |
| 409 | 48,9736 | -384 | 25,3175 | -1,0264 | 0,3175 |
| 410 | 51,3018 | -384 | 24,1837 | 1,3018 | -0,8163 |
| 411 | 51,3012 | -384 | 25,0783 | 1,3012 | 0,0783 |
| 412 | 49,3493 | -384 | 24,5455 | -0,6507 | -0,4545 |
| 413 | 48,8491 | -384 | 23,6128 | -1,1509 | -1,3872 |
| 414 | 48,3887 | -384 | 21,4072 | -1,6113 | -3,5928 |
| 415 | 49,061 | -384 | 23,4328 | -0,939 | -1,5672 |
| 416 | 52,2277 | -384 | 23,8101 | 2,2277 | -1,1899 |
| 417 | 47,9918 | -384 | 21,6457 | -2,0082 | -3,3543 |
| 418 | 52,5524 | -384 | 22,2941 | 2,5524 | -2,7059 |
| 419 | 51,0785 | -384 | 25,1568 | 1,0785 | 0,1568 |
| 420 | 50,8434 | -384 | 21,936 | 0,8434 | -3,064 |
| 421 | 50,8253 | -384 | 24,7643 | 0,8253 | -0,2357 |
| 422 | 48,2226 | -384 | 23,9623 | -1,7774 | -1,0377 |
| 423 | 49,3865 | -384 | 24,9185 | -0,6135 | -0,0815 |
| 424 | 51,9791 | -384 | 22,1504 | 1,9791 | -2,8496 |
| 425 | 50,5182 | -384 | 25,092 | 0,5182 | 0,092 |
| 426 | 49,7746 | -384 | 24,4005 | -0,2254 | -0,5995 |
| 427 | 49,0126 | -384 | 22,4226 | -0,9874 | -2,5774 |
| 428 | 48,2988 | -384 | 24,7311 | -1,7012 | -0,2689 |
| 429 | 49,6768 | -384 | 22,4826 | -0,3232 | -2,5174 |
| 430 | 47,9219 | -384 | 22,0612 | -2,0781 | -2,9388 |
| 431 | 48,3858 | -384 | 21,8884 | -1,6142 | -3,1116 |
| 432 | 48,9074 | -384 | 21,2333 | -1,0926 | -3,7667 |
| 433 | 49,1964 | -384 | 23,4808 | -0,8036 | -1,5192 |
| 434 | 49,0736 | -384 | 22,1715 | -0,9264 | -2,8285 |
| 435 | 48,0522 | -384 | 22,6403 | -1,9478 | -2,3597 |
| 436 | 52,5557 | -384 | 24,9251 | 2,5557 | -0,0749 |
| 437 | 48,1539 | -384 | 22,5002 | -1,8461 | -2,4998 |
| 438 | 52,2874 | -384 | 24,4484 | 2,2874 | -0,5516 |
| 439 | 50,218 | -384 | 23,0607 | 0,218 | -1,9393 |
| 440 | 53,084 | -384 | 24,1751 | 3,084 | -0,8249 |
| 441 | 50,5934 | -384 | 24,019 | 0,5934 | -0,981 |
| 442 | 48,1868 | -384 | 22,9373 | -1,8132 | -2,0627 |
| 443 | 49,3012 | -384 | 23,8308 | -0,6988 | -1,1692 |
| 444 | 50,8633 | -384 | 23,8321 | 0,8633 | -1,1679 |
| 445 | 50,1447 | -384 | 22,8859 | 0,1447 | -2,1141 |
| 446 | 51,3609 | -384 | 23,694 | 1,3609 | -1,306 |
| 447 | 48,3571 | -384 | 21,5009 | -1,6429 | -3,4991 |
| 448 | 48,0065 | -384 | 21,6716 | -1,9935 | -3,3284 |


| Particle | X | Hit $Y=$ | Z | X-50 | Z-25 |
| :---: | :---: | :---: | :---: | :---: | :---: |
| 449 | 48,9974 | -384 | 23,3798 | -1,0026 | -1,6202 |
| 450 | 48,1281 | -384 | 21,9492 | -1,8719 | -3,0508 |
| 451 | 48,0076 | -384 | 21,163 | -1,9924 | -3,837 |
| 452 | 50,4812 | -384 | 22,0992 | 0,4812 | -2,9008 |
| 453 | 52,9272 | -384 | 24,3914 | 2,9272 | -0,6086 |
| 454 | 50,708 | -384 | 21,485 | 0,708 | -3,515 |
| 455 | 51,3458 | -384 | 25,2267 | 1,3458 | 0,2267 |
| 456 | 49,7651 | -384 | 24,9394 | -0,2349 | -0,0606 |
| 457 | 50,8082 | -384 | 25,0425 | 0,8082 | 0,0425 |
| 458 | 49,254 | -384 | 24,0952 | -0,746 | -0,9048 |
| 459 | 50,3156 | -384 | 21,9172 | 0,3156 | -3,0828 |
| 460 | 48,8415 | -384 | 21,0456 | -1,1585 | -3,9544 |
| 461 | 47,9983 | -384 | 20,9247 | -2,0017 | -4,0753 |
| 462 | 48,4051 | -384 | 21,1969 | -1,5949 | -3,8031 |
| 463 | 48,7119 | -384 | 20,8366 | -1,2881 | -4,1634 |
| 464 | 50,8429 | -384 | 24,5637 | 0,8429 | -0,4363 |
| 465 | 49,3806 | -384 | 20,9881 | -0,6194 | -4,0119 |
| 466 | 49,1428 | -384 | 25,0597 | -0,8572 | 0,0597 |
| 467 | 48,5113 | -384 | 21,3288 | -1,4887 | -3,6712 |
| 468 | 47,9096 | -384 | 21,9529 | -2,0904 | -3,0471 |
| 469 | 50,2671 | -384 | 23,7988 | 0,2671 | -1,2012 |
| 470 | 48,1314 | -384 | 21,9218 | -1,8686 | -3,0782 |
| 471 | 49,3181 | -384 | 25,294 | -0,6819 | 0,294 |
| 472 | 49,5864 | -384 | 25,0688 | -0,4136 | 0,0688 |
| 473 | 49,764 | -384 | 22,0777 | -0,236 | -2,9223 |
| 474 | 48,5392 | -384 | 20,9174 | -1,4608 | -4,0826 |
| 475 | 48,3494 | -384 | 24,5698 | -1,6506 | -0,4302 |
| 476 | 47,9999 | -384 | 22,0705 | -2,0001 | -2,9295 |
| 477 | 49,187 | -384 | 22,1908 | -0,813 | -2,8092 |
| 478 | 49,9791 | -384 | 21,2614 | -0,0209 | -3,7386 |
| 479 | 50,334 | -384 | 24,3956 | 0,334 | -0,6044 |
| 480 | 50,8207 | -384 | 24,0651 | 0,8207 | -0,9349 |
| 481 | 52,0546 | -384 | 21,4972 | 2,0546 | -3,5028 |
| 482 | 49,7191 | -384 | 24,976 | -0,2809 | -0,024 |
| 483 | 48,9947 | -384 | 21,6461 | -1,0053 | -3,3539 |
| 484 | 48,7458 | -384 | 21,4433 | -1,2542 | -3,5567 |
| 485 | 48,0233 | -384 | 22,2303 | -1,9767 | -2,7697 |
| 486 | 47,9276 | -384 | 22,7697 | -2,0724 | -2,2303 |
| 487 | 49,7032 | -384 | 25,2545 | -0,2968 | 0,2545 |
| 488 | 49,9602 | -384 | 21,9464 | -0,0398 | -3,0536 |
| 489 | 49,5192 | -384 | 25,5119 | -0,4808 | 0,5119 |
| 490 | 48,1875 | -384 | 23,4758 | -1,8125 | -1,5242 |
| 491 | 53,3021 | -384 | 23,7638 | 3,3021 | -1,2362 |
| 492 | 50,9265 | -384 | 24,9041 | 0,9265 | -0,0959 |
| 493 | 52,5693 | -384 | 23,2867 | 2,5693 | -1,7133 |
| 494 | 52,7048 | -384 | 23,4802 | 2,7048 | -1,5198 |
| 495 | 50,789 | -384 | 21,772 | 0,789 | -3,228 |
| 496 | 52,4305 | -384 | 22,0575 | 2,4305 | -2,9425 |
| 497 | 48,1127 | -384 | 24,0296 | -1,8873 | -0,9704 |
| 498 | 48,2 | -384 | 23,8832 | -1,8 | -1,1168 |
| 499 | 50,1384 | -384 | 22,4949 | 0,1384 | -2,5051 |
| 500 | 52,5817 | -384 | 23,6031 | 2,5817 | -1,3969 |

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